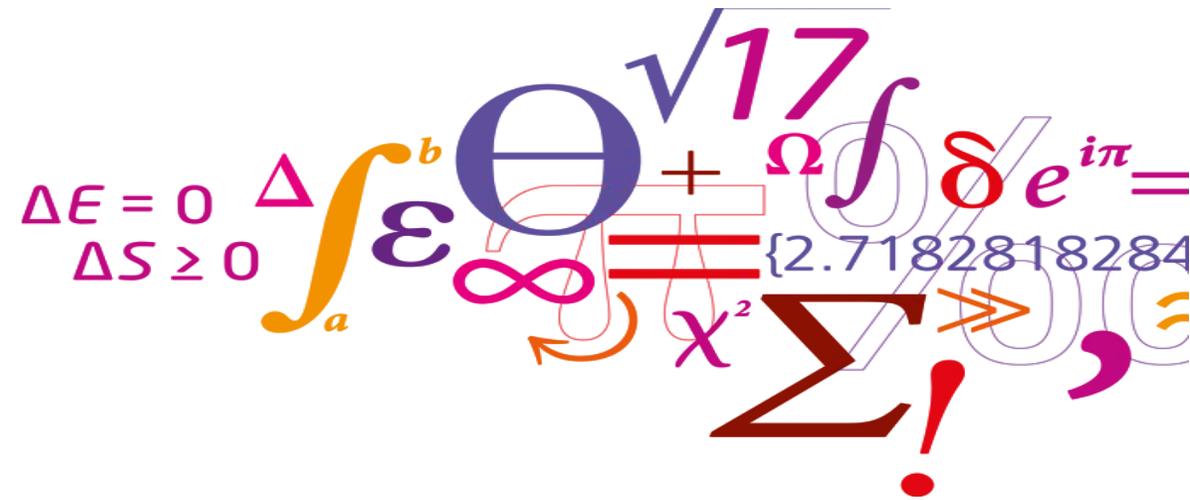


Quantum Materials: An introduction

Yunzhong Chen

*Department of Energy Conversion and Storage,
Technical University of Denmark*



DTU Energy

Department of Energy Conversion and Storage

Outline

- **1. What are quantum materials**
- **2. Materials and synthesis**
- **3. Emergent functions at the interface between two oxide insulators**

What are quantum materials ?

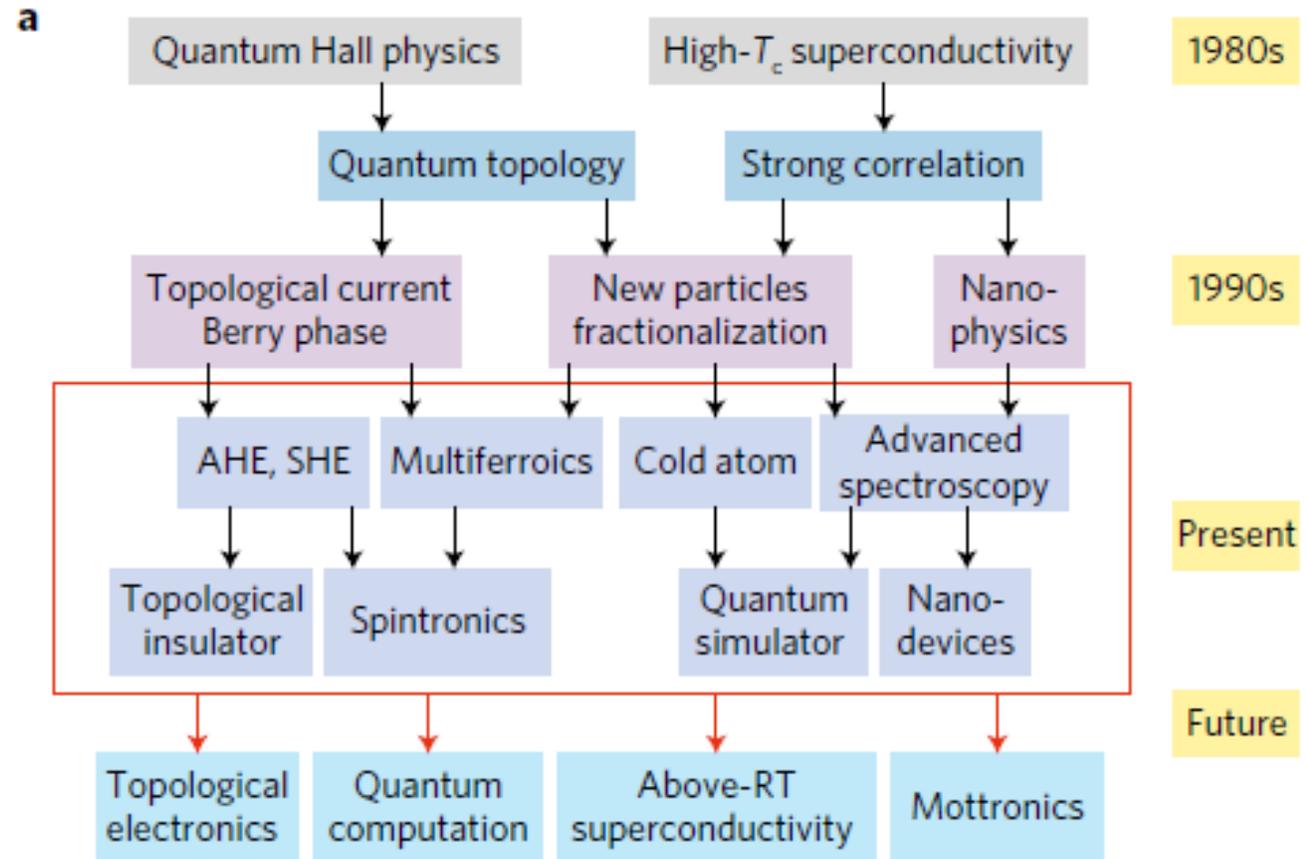
Quantum materials (QM) are solids with exotic physical properties, arising from the quantum mechanical properties of their constituent electrons; such materials have great scientific and/or technological potential.

Themes of modern quantum Materials:

Order and Symmetry; Topology;

Entanglement; Correlations; Dynamics

Brief history of the research on physics of QM



REVIEW ARTICLES

PUBLISHED ONLINE: 25 SEPTEMBER 2017 | DOI: 10.1038/NPHYS4274

nature
physics

Emergent functions of quantum materials

Yoshinori Tokura^{1,2*}, Masashi Kawasaki^{1,2} and Naoto Nagaosa^{1,2}

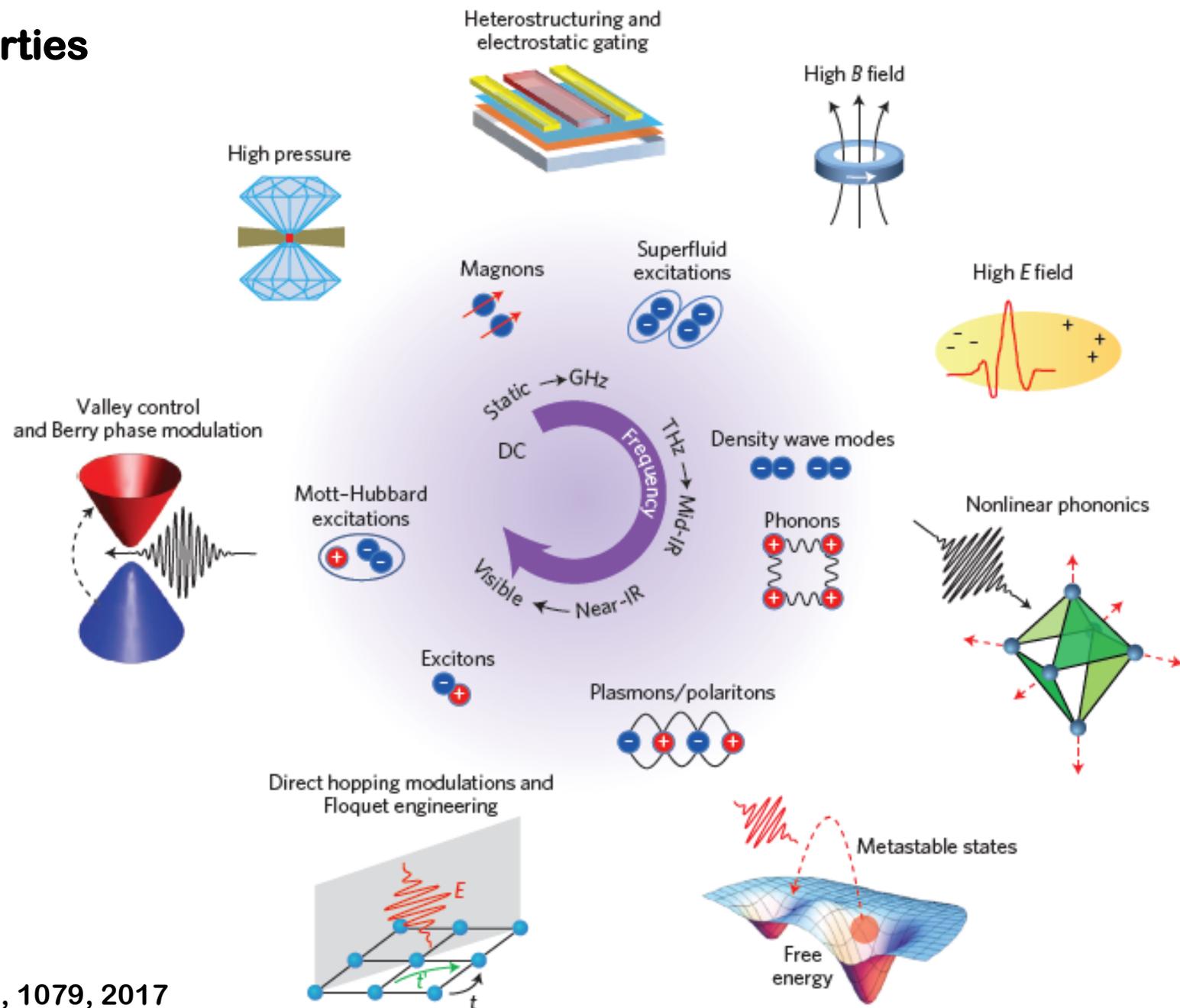
The rise of quantum materials

Nature Physics. 12, 105, 2016

Emergent phenomena are common in condensed matter. Their study now extends beyond strongly correlated electron systems, giving rise to the broader concept of quantum materials.

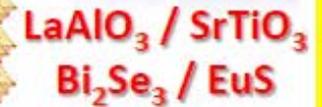
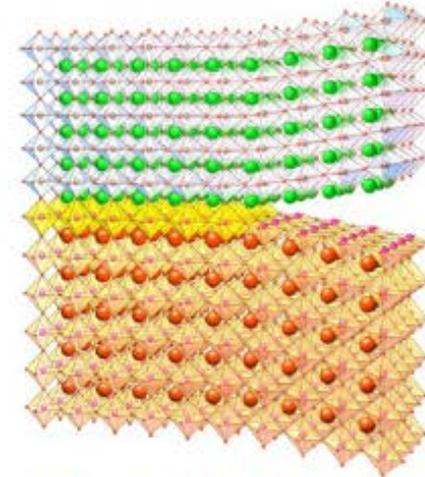
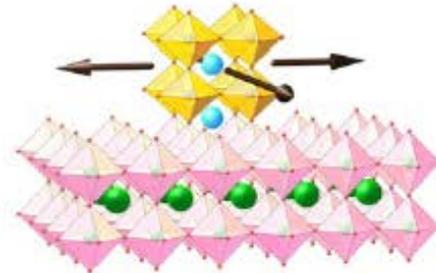
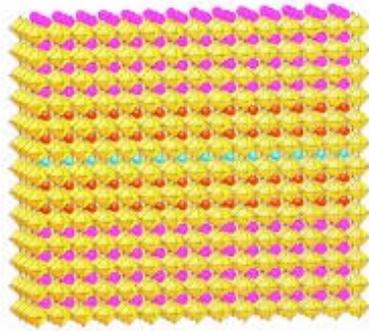
- Magnetism
- High temperature superconductors
- Topological Insulators
- Oxide heterostructures**
- Van der Waals heterostructures
- Monolayer "transition-metal dichalcogenides"
-

The trend: on-demand properties



“Artificial” Quantum Materials

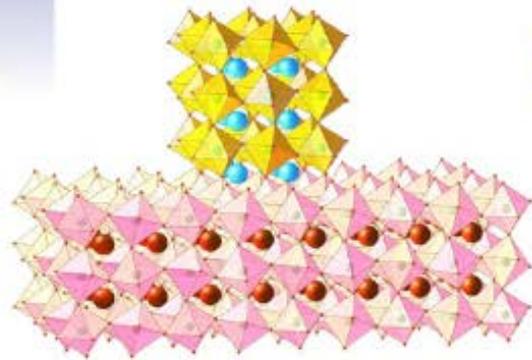
Interface Engineering



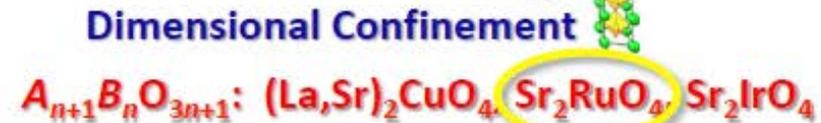
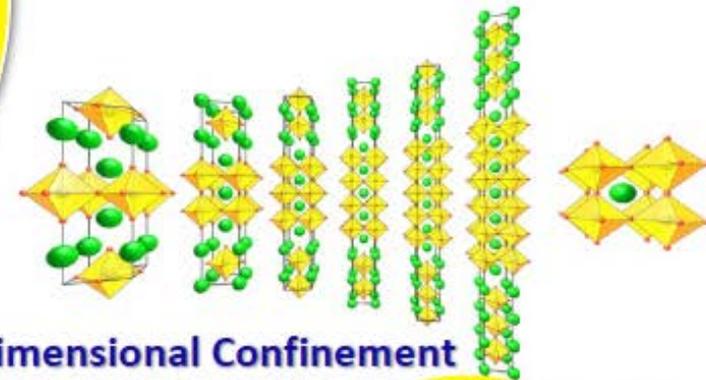
Bulk Quantum Materials



ARPES



Polarization Doping & Proximity Effects
(from juxtaposed competing)



My Research

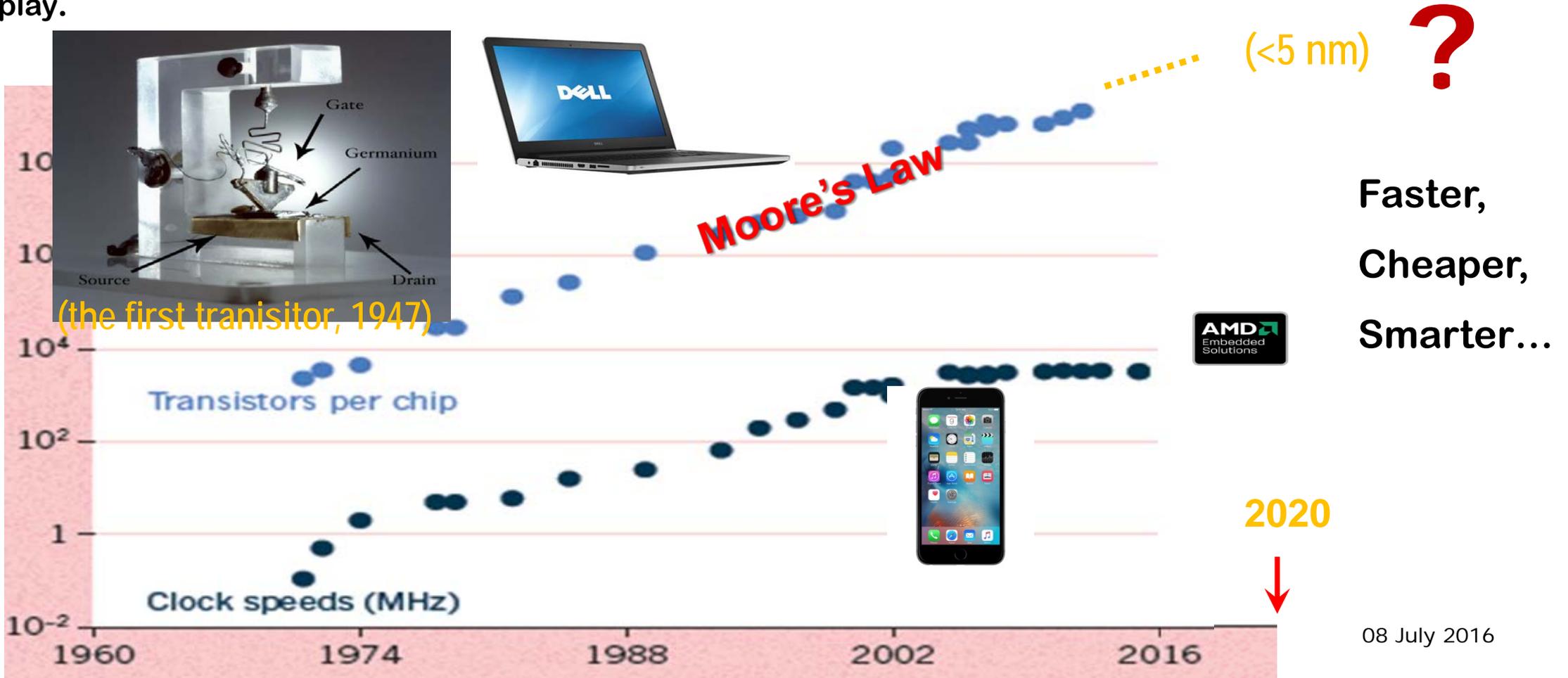
- **Conducting Oxide Interfaces for Electronics**
- **Conducting Oxide Interfaces for Ionics and Electrocatalysts**



Two Key Challenges of Current Semiconductor Technology

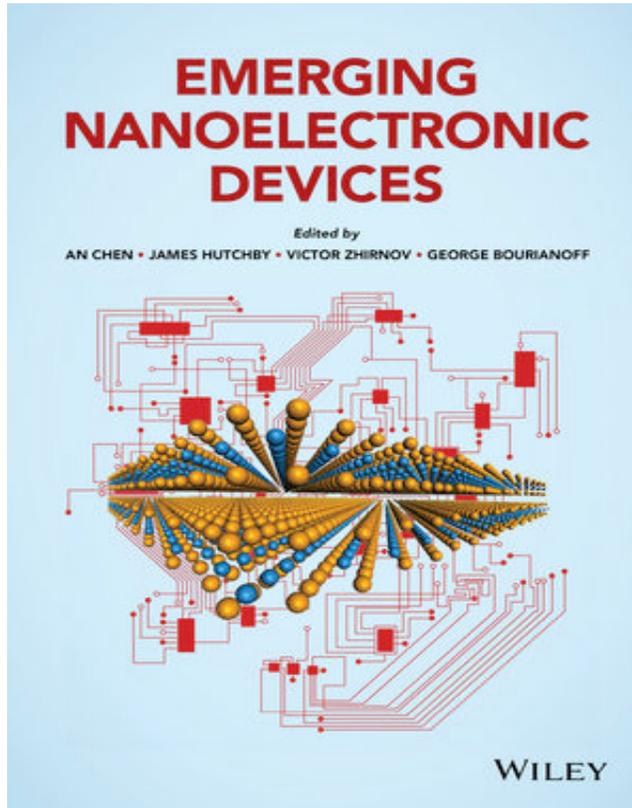
1. Material limit of Si is going to be meet

What will happen when continued scaling is no longer possible with silicon because quantum effects have come into play.

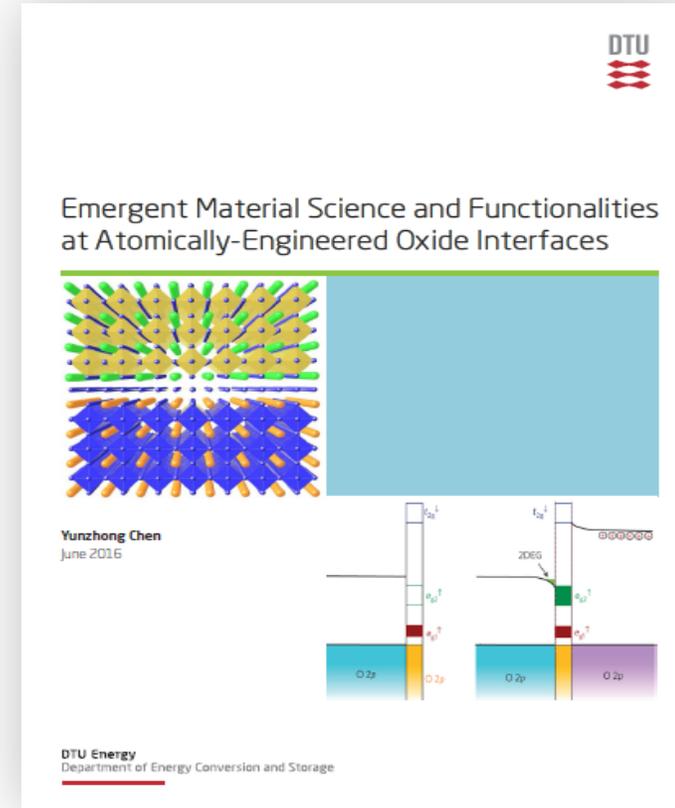


Beyond CMOS : Emergent Research Device Materials

Marked in 2007 edition of The International Technology Roadmap for Semiconductors



2015



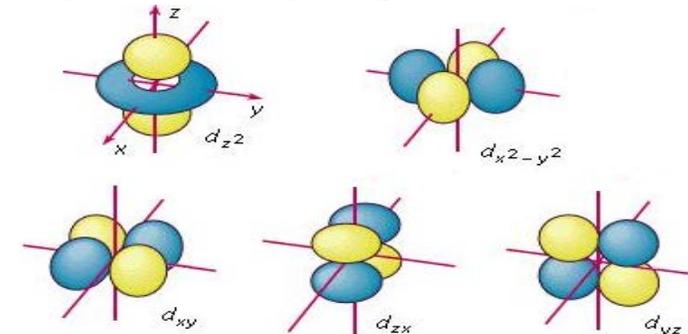
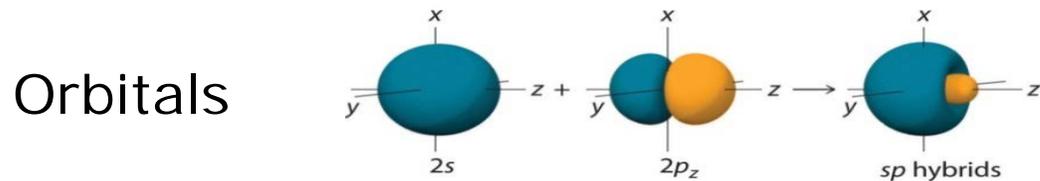
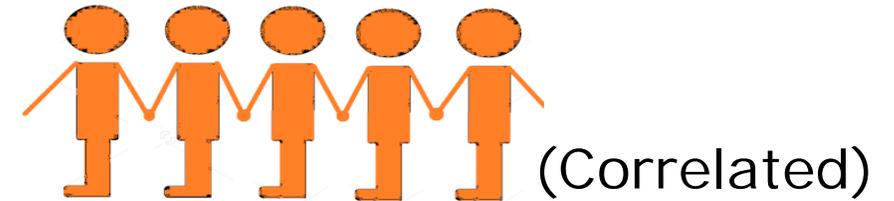
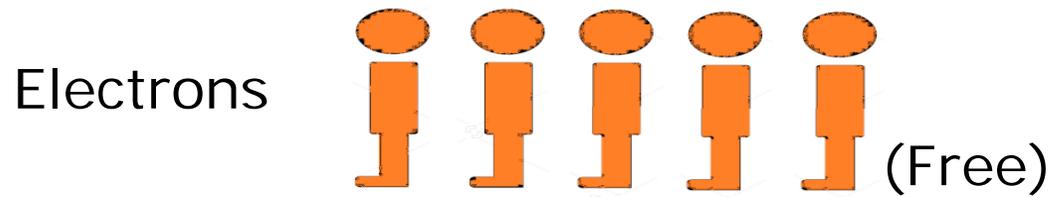
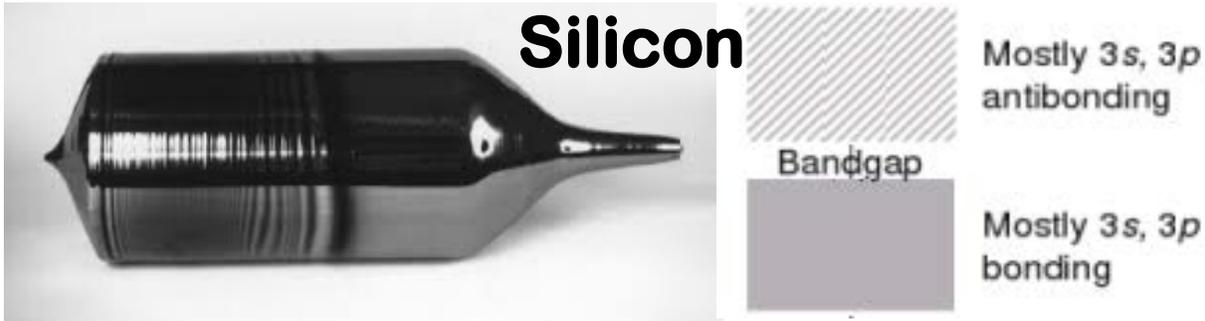
2016

To develop a new generation of devices based on new physical principles ...

1. Oxide Electronics Emerge

1.1 Why Oxides, compared to Si?

a. Rich Physics due to correlated electrons;

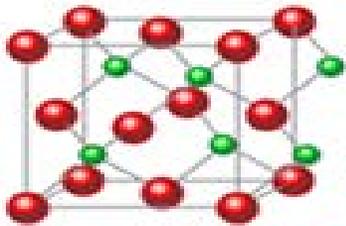


b. Multi-functions in compatible structures;

Silicon/III-V Compounds
(Semiconductor, Insulator)



Si



GaAs

Diamond/zinc-blende

phenomena in the bulk

Colossal magnetoresistance
 LnMnO_3

Relaxor and high-k
 $\text{Pb}(\text{MgNb})\text{O}_3$

Ferroelectricity
 BaTiO_3

Multiferroicity
 BiFeO_3

High temperature ferromagnetism
double perovskites

Perovskite oxides

Strain induced orbital order

Electronic reconstruction and enhanced mobility

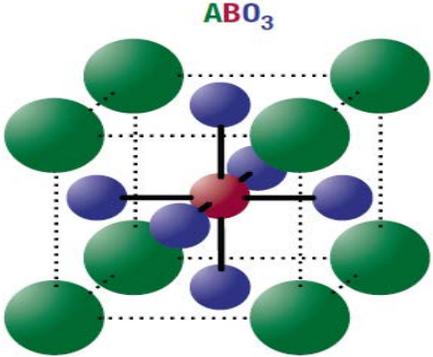
Multiferroicity
 $\text{BaTiO}_3/\text{CoFe}_2\text{O}_4$

at interfaces, in heterostructures

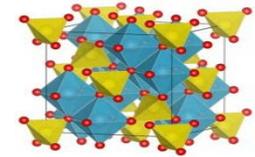
Resistive RAM

Magneto-electronic junctions

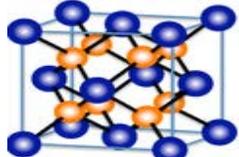
Spin filtering



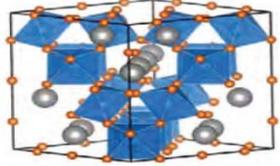
Perovskite



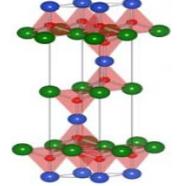
Spinel (AB_2O_4)



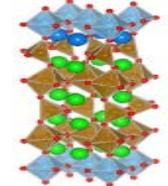
Fluorite (AO_2)



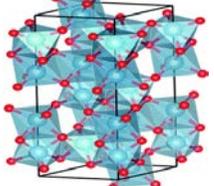
Pyrochlore ($\text{A}_2\text{B}_2\text{O}_7$)



Delafossite (ABO_2)



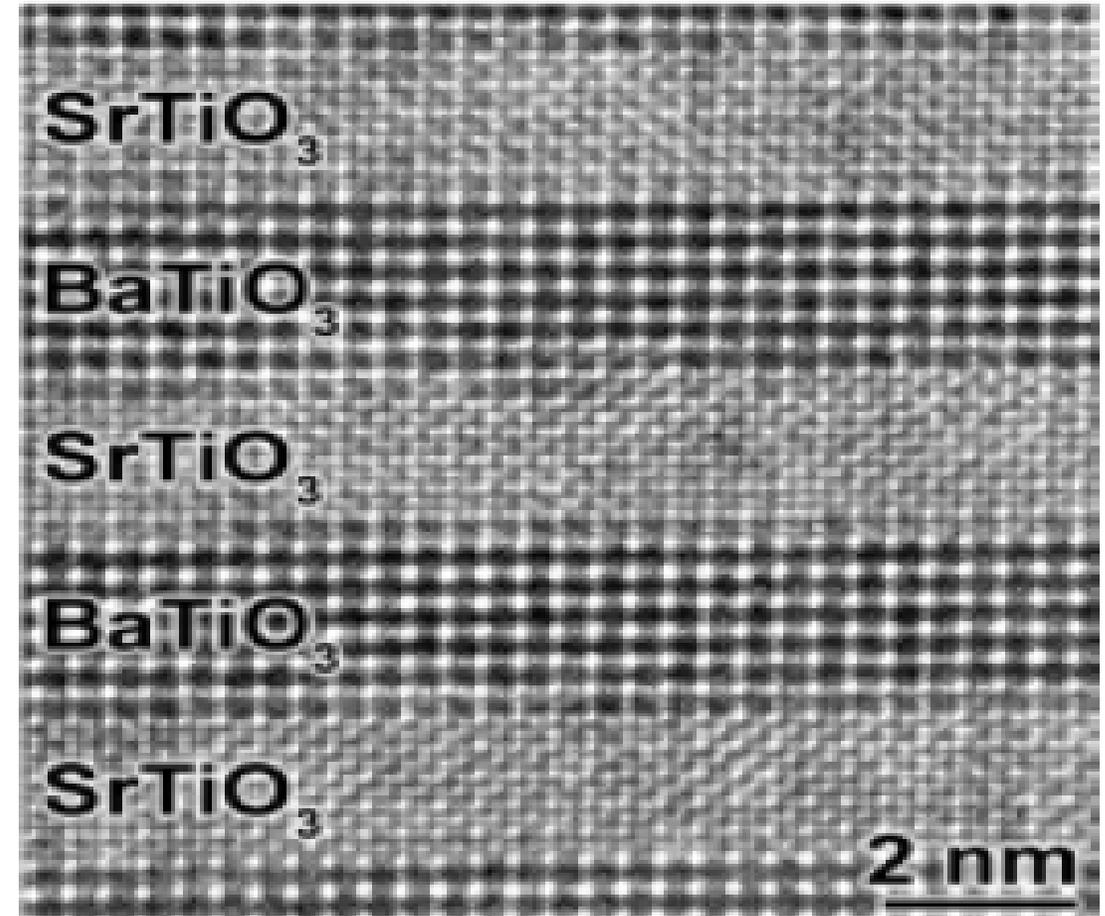
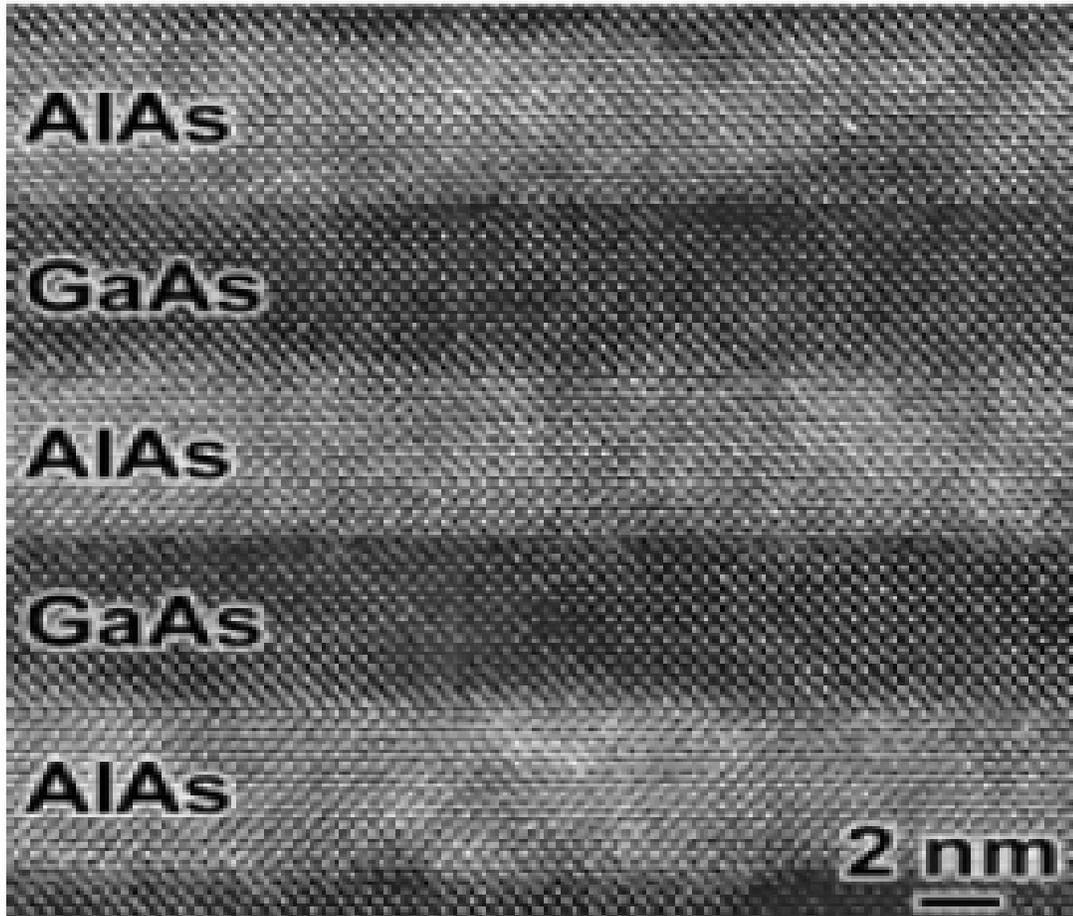
Brownmillerite ($\text{ABO}_{2.5}$)



Corundum (A_2O_3)

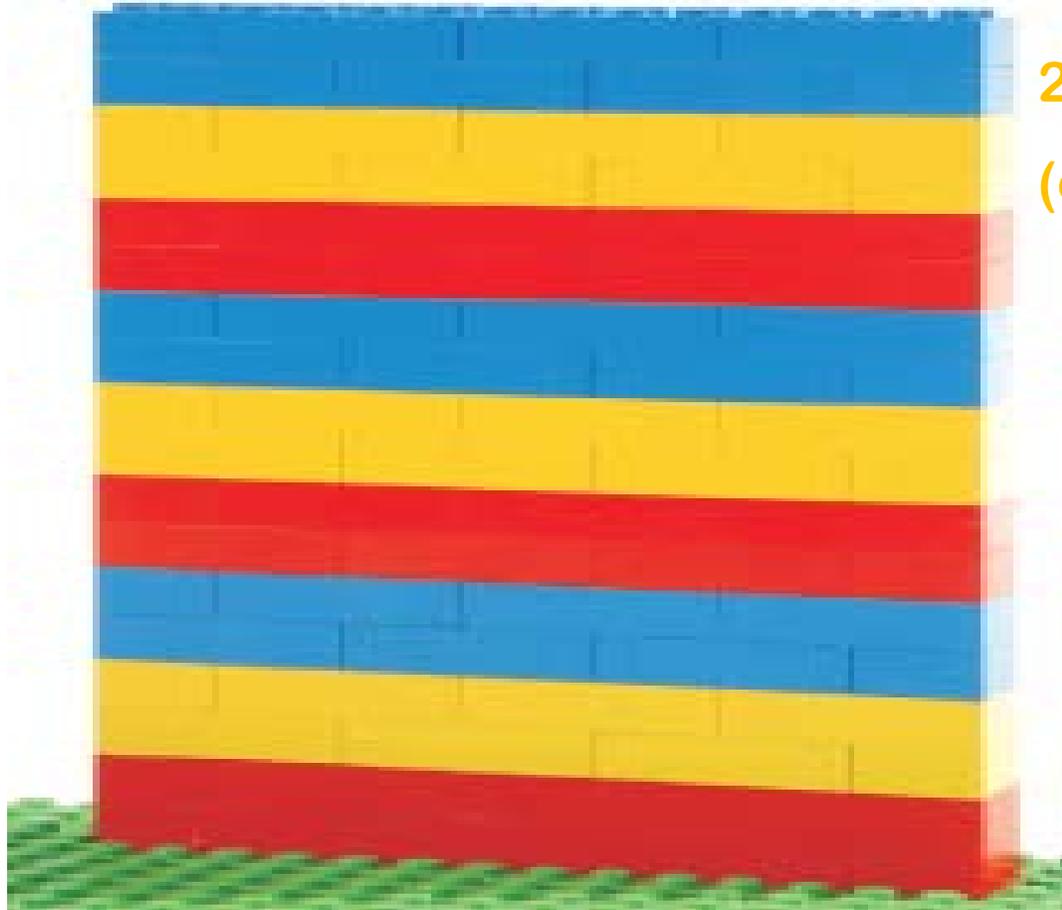
C. Technology progress in oxide thin film growth

In the past two decades



D. G. Scholm *et al.* *J. Am. Ceram. Soc.* **91**, 24298(2008)

Build up your own superlattice



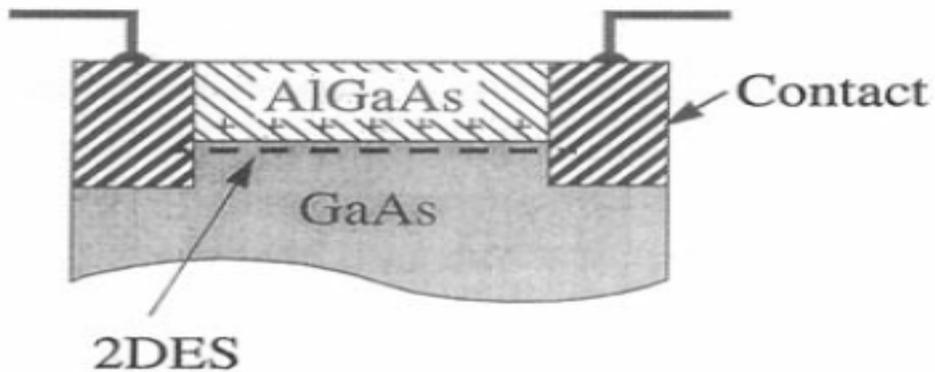
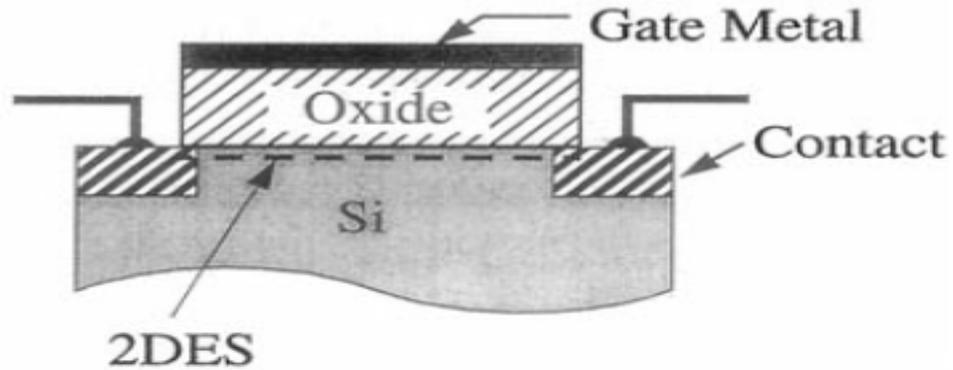
2272 perovskite oxides

(out of 2454 materials with perovskite structure)



Lego version of an oxide superlattice structure

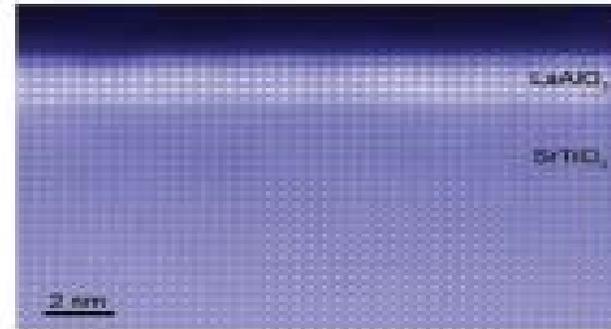
1.2 Conducting Interface is the device



2DEGs in Si-based MOSFET and GaAs/AlGaAs



A. Ohtomo and H. Y. Hwang, Nature, 427, 423



REVIEW

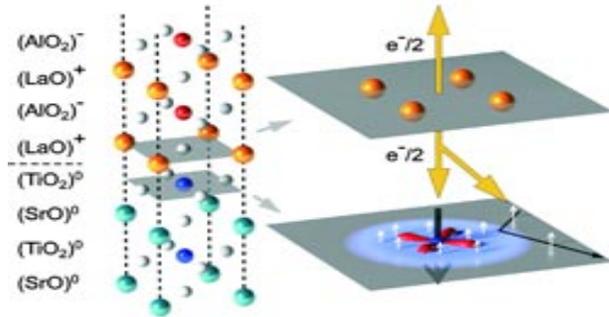
Oxide Interfaces—An Opportunity for Electronics

J. Mannhart^{1*} and D. G. Schlom^{2*} *Science*, 327, 1607, 2010

1.3 Oxide Interface remains in its infancy

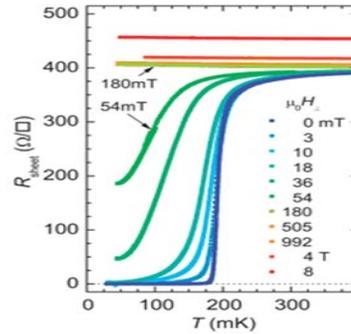
a. Novel physical properties and phenomena

Ferromagnetism, Superconductivity, metal-insulator transitions, large spin-orbital coupling...



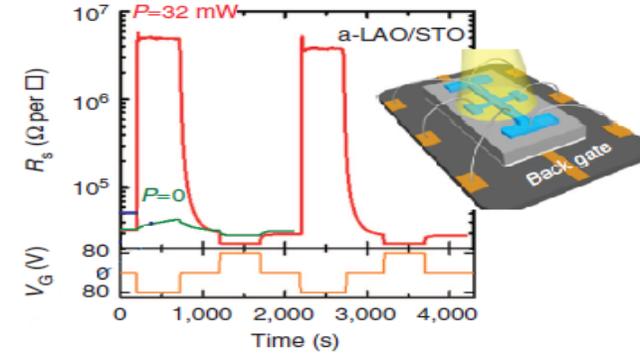
Magnetism

A. Brinkman *et al.*, Nature Mater. 2007



Superconductivity

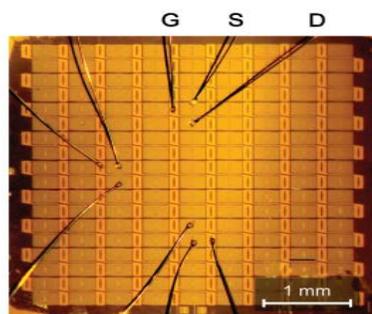
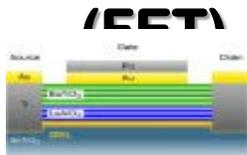
N. Reyren *et al.* Science, 2007



Visible light enhanced field effect

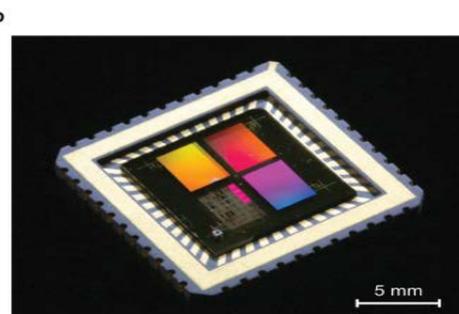
Y. Lei *et al.* Nature Commun, 2014

b. Demonstration of field effect transistors

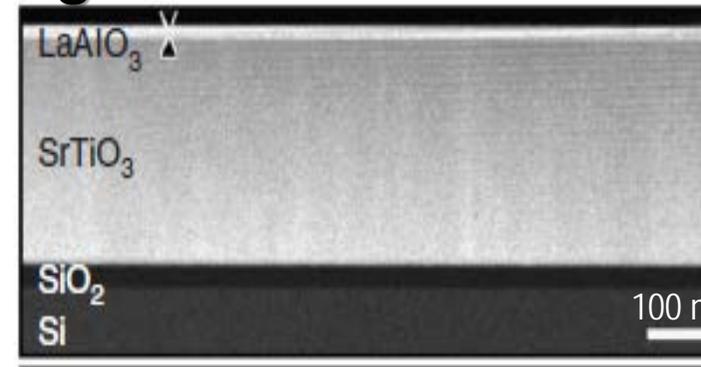


Photograph of an array of LAO/STO FET and a chip carrying 700 000 FETs.

R. Jany *et al.* Adv. Mater. Interfaces 1, 1300031 (2014)

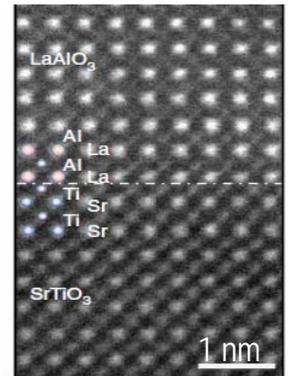


c. Integration with Si

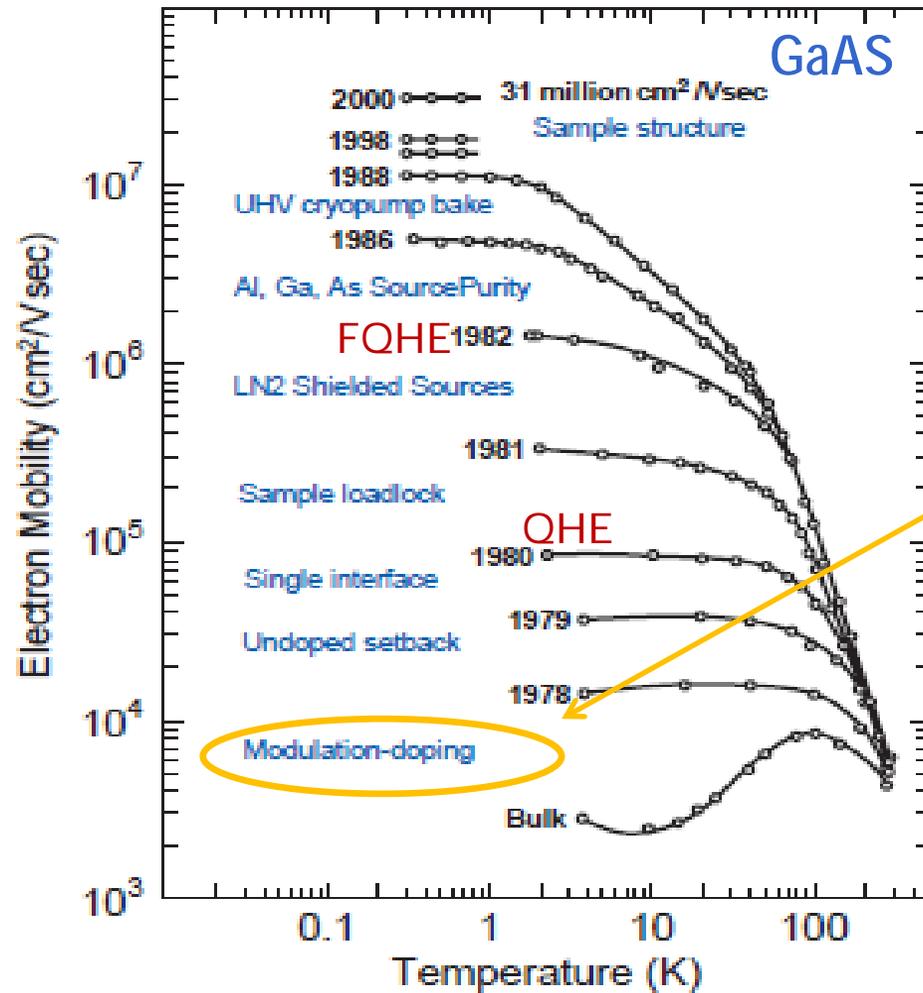


LAO/STO heterointerface on Si.

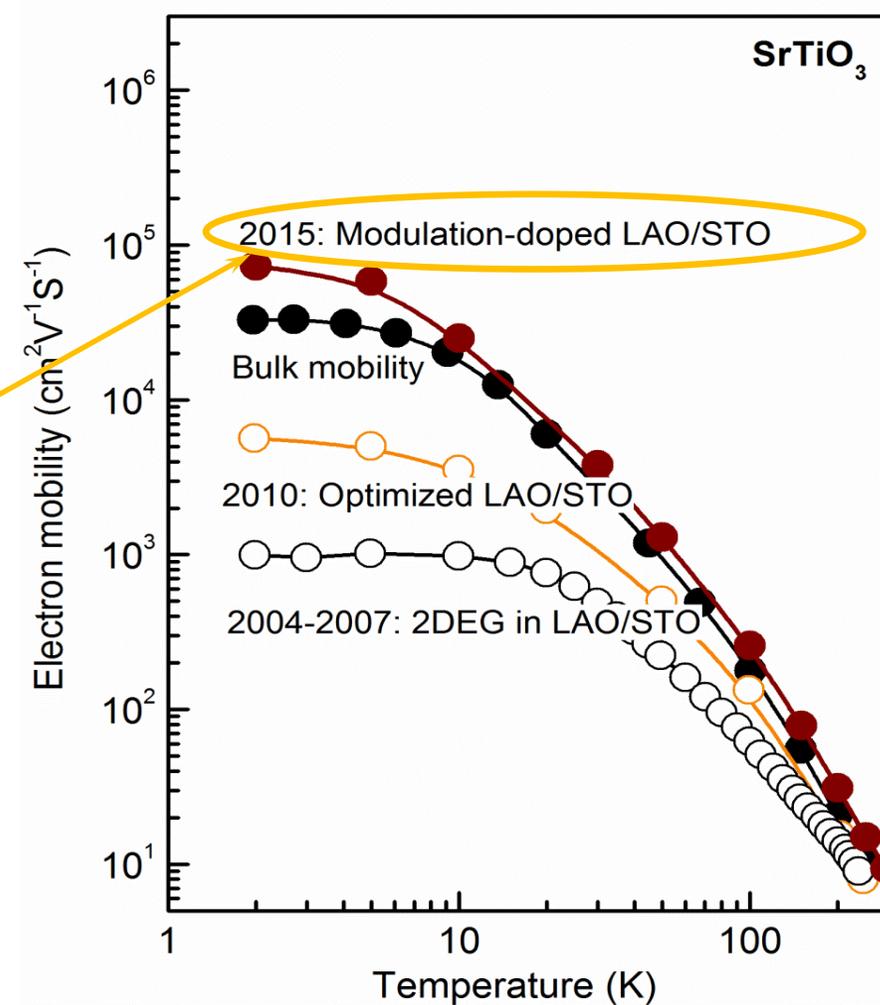
J.W. Park *et al.* Nature Commun. 1:94, 1096 (2010)



One of the key challenges: improving the cleanness of the interface.

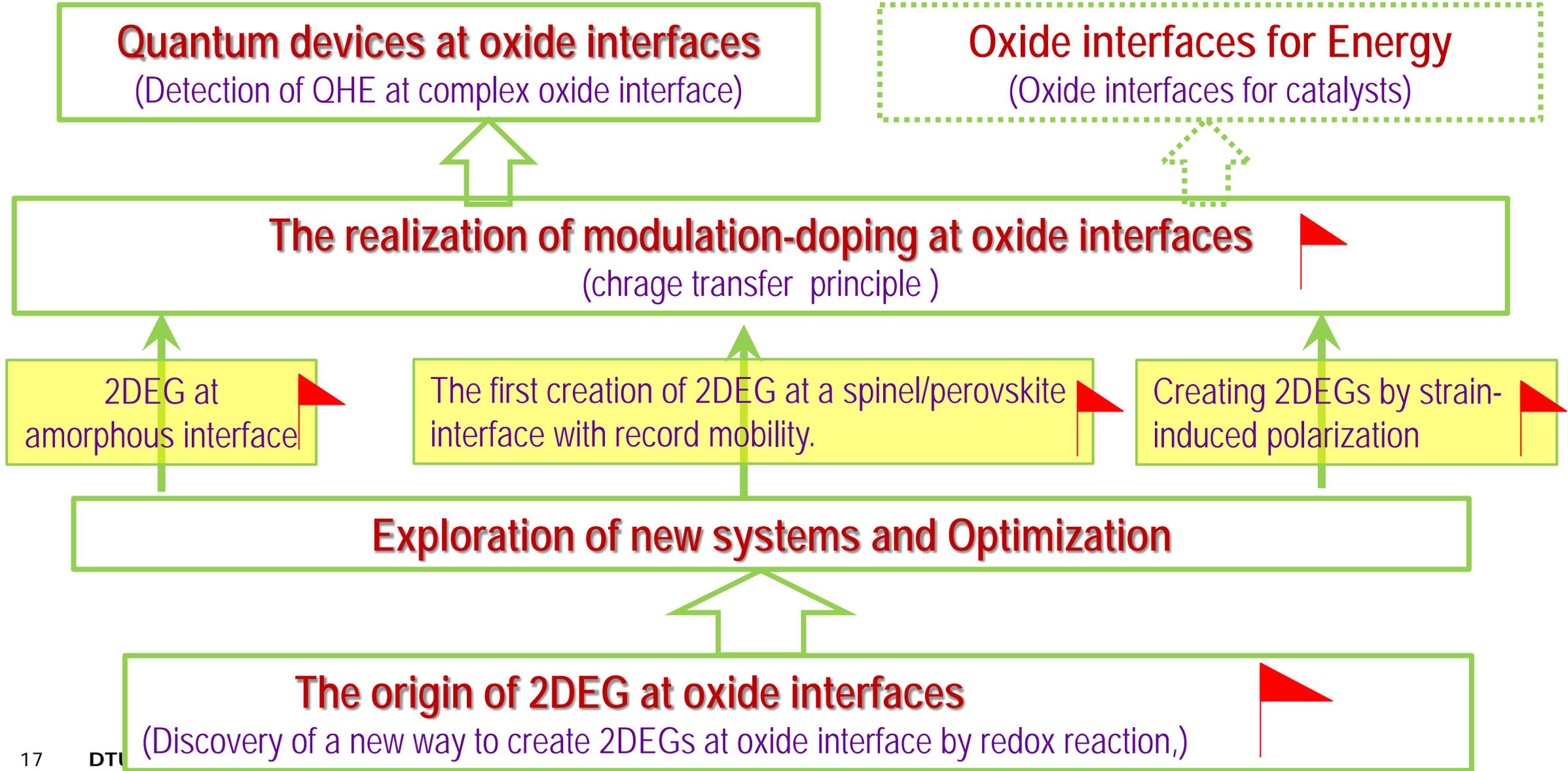


History of improvements in the mobility of 2DEG in GaAs-AlGaAs heterostructure.



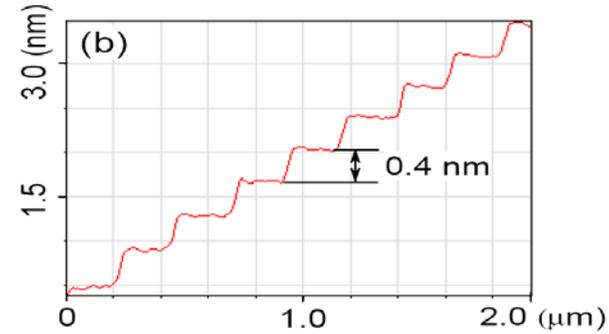
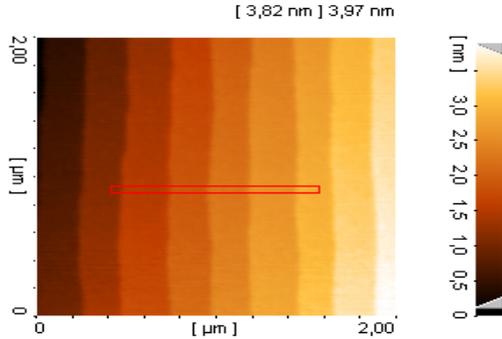
Mobility History of 2DEG in LAO/STO heterostructure

1.4 DTU's contributions



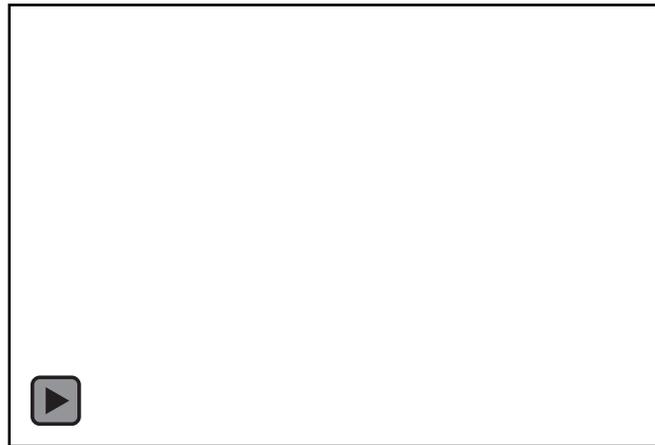
Experimental Oxide Thin Film growth with atomical control at DTU Energy

a. Atomically flat substrates



Regular flat terrace surface with terrace height of one unit cell (0.39 nm).

b. Atomically In-situ control during film growth (PLD-RHEED)



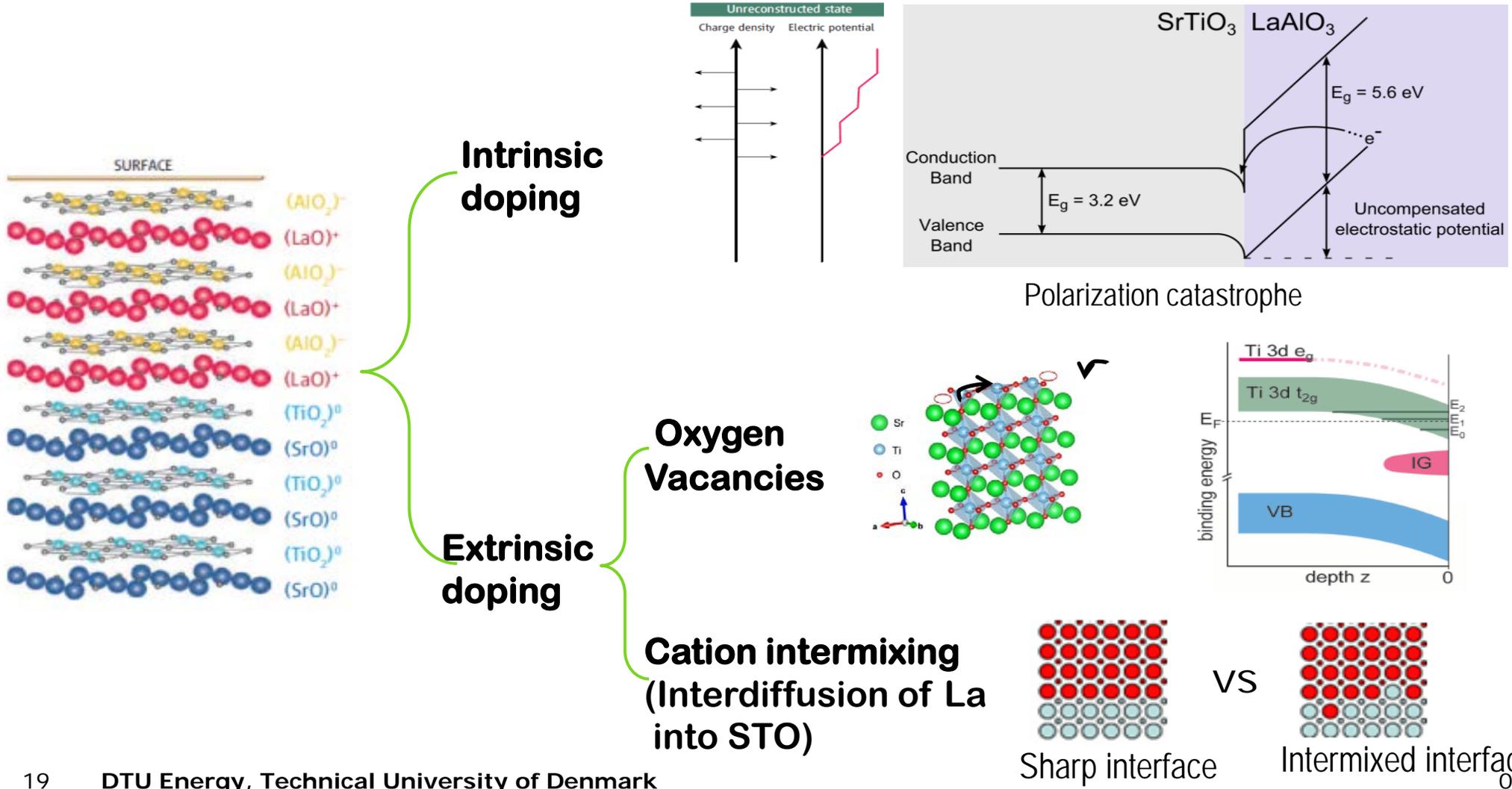
Pulsed laser deposition



In-situ RHEED

2. Creation of oxide 2DEG by redox reaction

2.1 10-year debates on the origin of 2DEG at LAO/STO interface

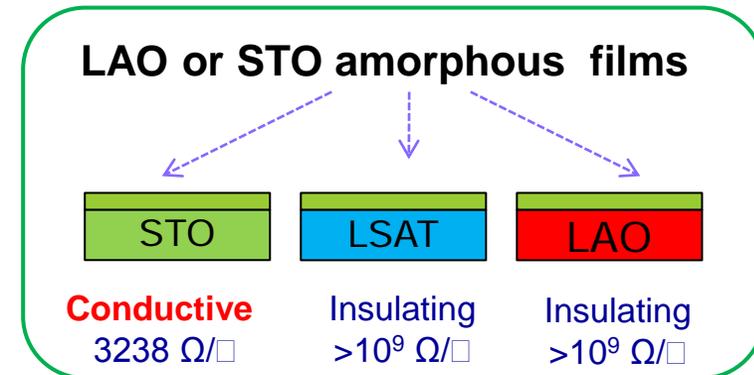
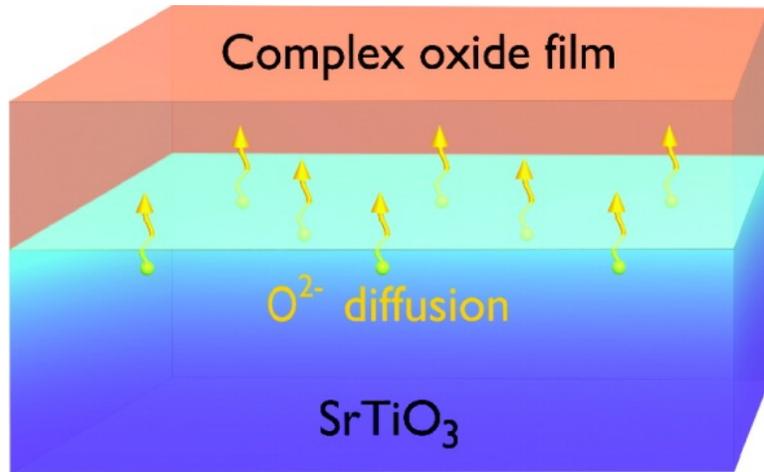


The key is to identify the right origin of the defects.

a. Oxide heterostructures are often grown at high temperatures, where ions exchange introduces the complexity



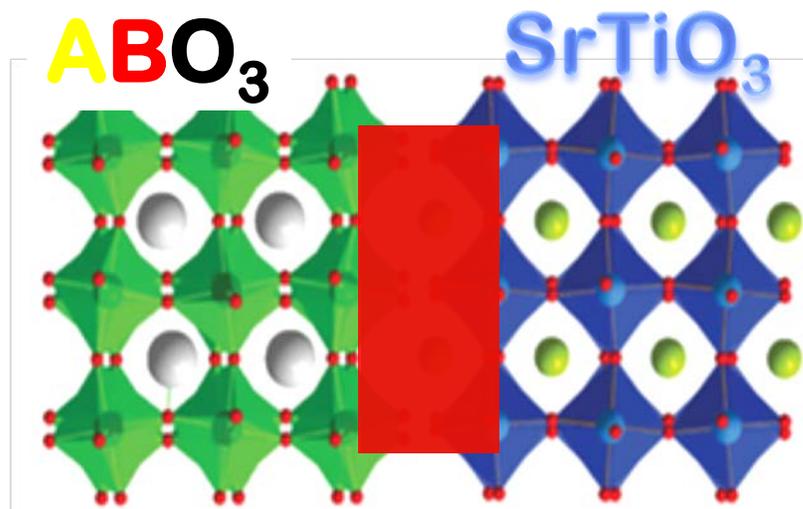
b. Our finding: Room temperature redox reaction at oxide interfaces



(No polarity, no thermal-induced oxygen conduction, no intermixing)

Y. Z. Chen *et al.* *Nano letters* 11, 3774 (2011)

All perovskite $ABO_3/SrTiO_3$ interfaces fit in Redox reactions regime



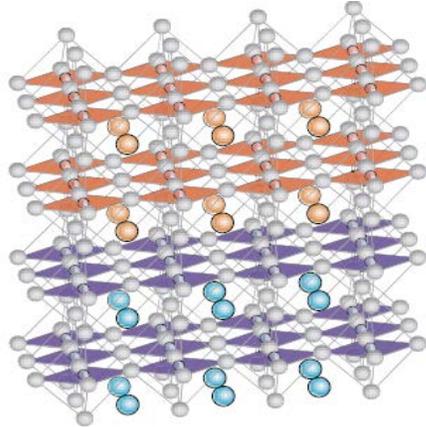
A powerful tool to design oxide 2DEG.

Periodic Table of the Elements © www.elementsdatabase.com

H ¹																	He ²
Li ³	Be ⁴											B ⁵	C ⁶	N ⁷	O ⁸	F ⁹	Ne ¹⁰
Na ¹¹	Mg ¹²											Al ¹³	Si ¹⁴	P ¹⁵	S ¹⁶	Cl ¹⁷	Ar ¹⁸
K ¹⁹	Ca ²⁰	Sc ²¹	Ti ²²	V ²³	Cr ²⁴	Mn ²⁵	Fe ²⁶	Co ²⁷	Ni ²⁸	Cu ²⁹	Zn ³⁰	Ga ³¹	Ge ³²	As ³³	Se ³⁴	Br ³⁵	Kr ³⁶
Rb ³⁷	Sr ³⁸	Y ³⁹	Zr ⁴⁰	Nb ⁴¹	Mo ⁴²	Tc ⁴³	Ru ⁴⁴	Rh ⁴⁵	Pd ⁴⁶	Ag ⁴⁷	Cd ⁴⁸	In ⁴⁹	Sn ⁵⁰	Sb ⁵¹	Te ⁵²	I ⁵³	Xe ⁵⁴
Cs ⁵⁵	Ba ⁵⁶	La ⁵⁷	Hf ⁷²	Ta ⁷³	W ⁷⁴	Re ⁷⁵	Os ⁷⁶	Ir ⁷⁷	Pt ⁷⁸	Au ⁷⁹	Hg ⁸⁰	Tl ⁸¹	Pb ⁸²	Bi ⁸³	Po ⁸⁴	At ⁸⁵	Rn ⁸⁶
Fr ⁸⁷	Ra ⁸⁸	Ac ⁸⁹	Unq ¹⁰⁴	Unp ¹⁰⁵	Unh ¹⁰⁶	Uns ¹⁰⁷	Uno ¹⁰⁸	Une ¹⁰⁹	Unn ¹¹⁰								
DTU Energy,		Lanthe-nides	La ⁵⁷	Ce ⁵⁸	Pr ⁵⁹	Nd ⁶⁰	Pm ⁶¹	Sm ⁶²	Eu ⁶³	Gd ⁶⁴	Tb ⁶⁵	Dy ⁶⁶	Ho ⁶⁷	Er ⁶⁸	Tm ⁶⁹	Yb ⁷⁰	Lu ⁷¹

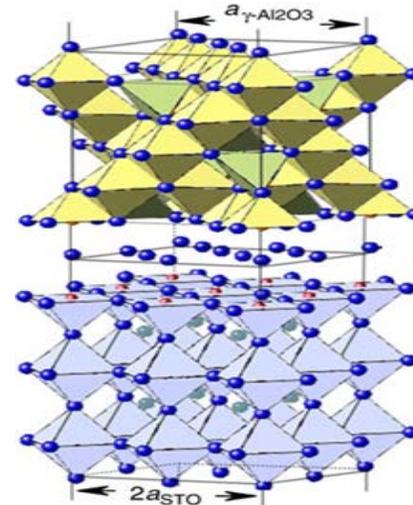
2. Materials of oxide 2DEGs

1. Polar oxide interfaces;



Ohtomo & Hwang
Nature, 427, 423 (2004)

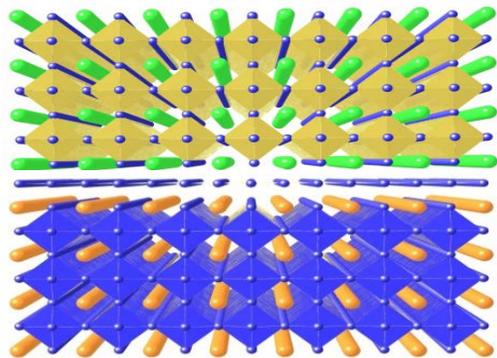
LaAlO3/SrTiO3



Chen *et al.* *Nature Commun.*
4, 1371 (2013)

Gamma-Al2O3/SrTiO3

2. Nonpolar interfaces;

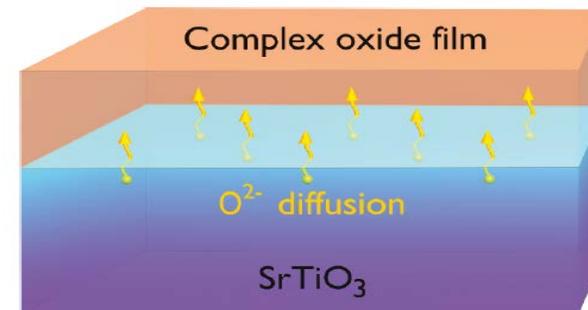


Chen *et al.* *Nano letters*
11, 3774 (2015)

CaZrO3/SrTiO3

DTU Energy, Technical University of Denmark

3. Disordered structure



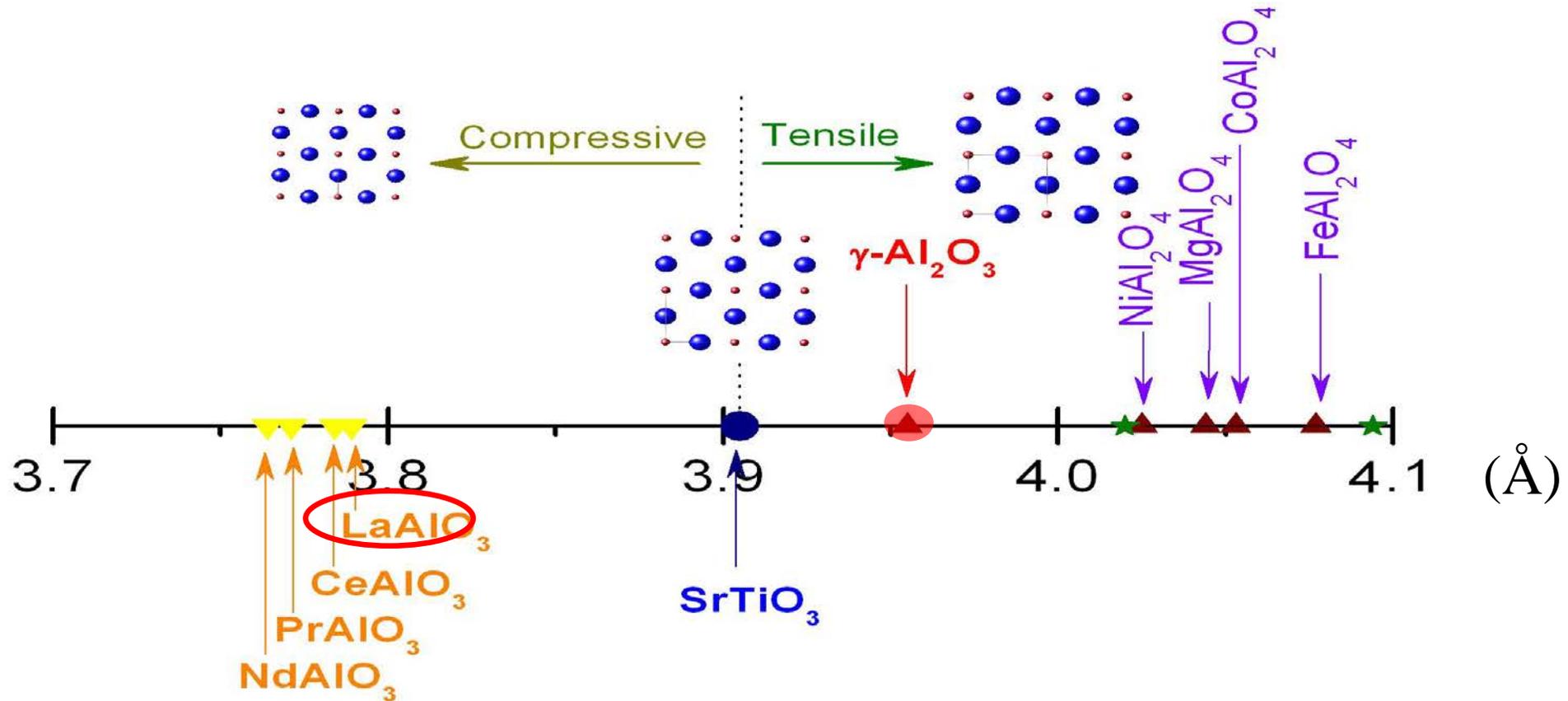
Chen *et al.* *Nano letters*
11, 3774 (2011)

Amorphous-LaAlO3/SrTiO3

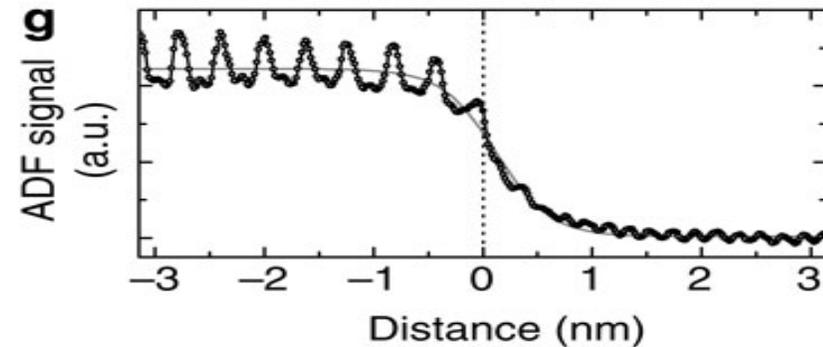
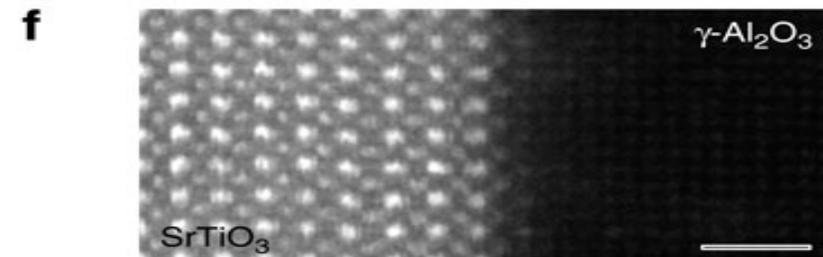
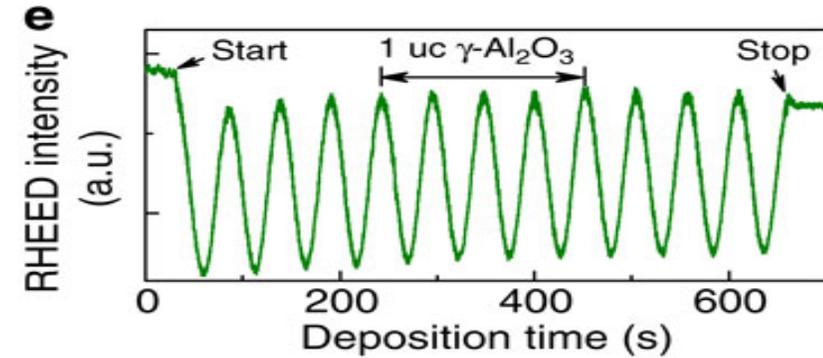
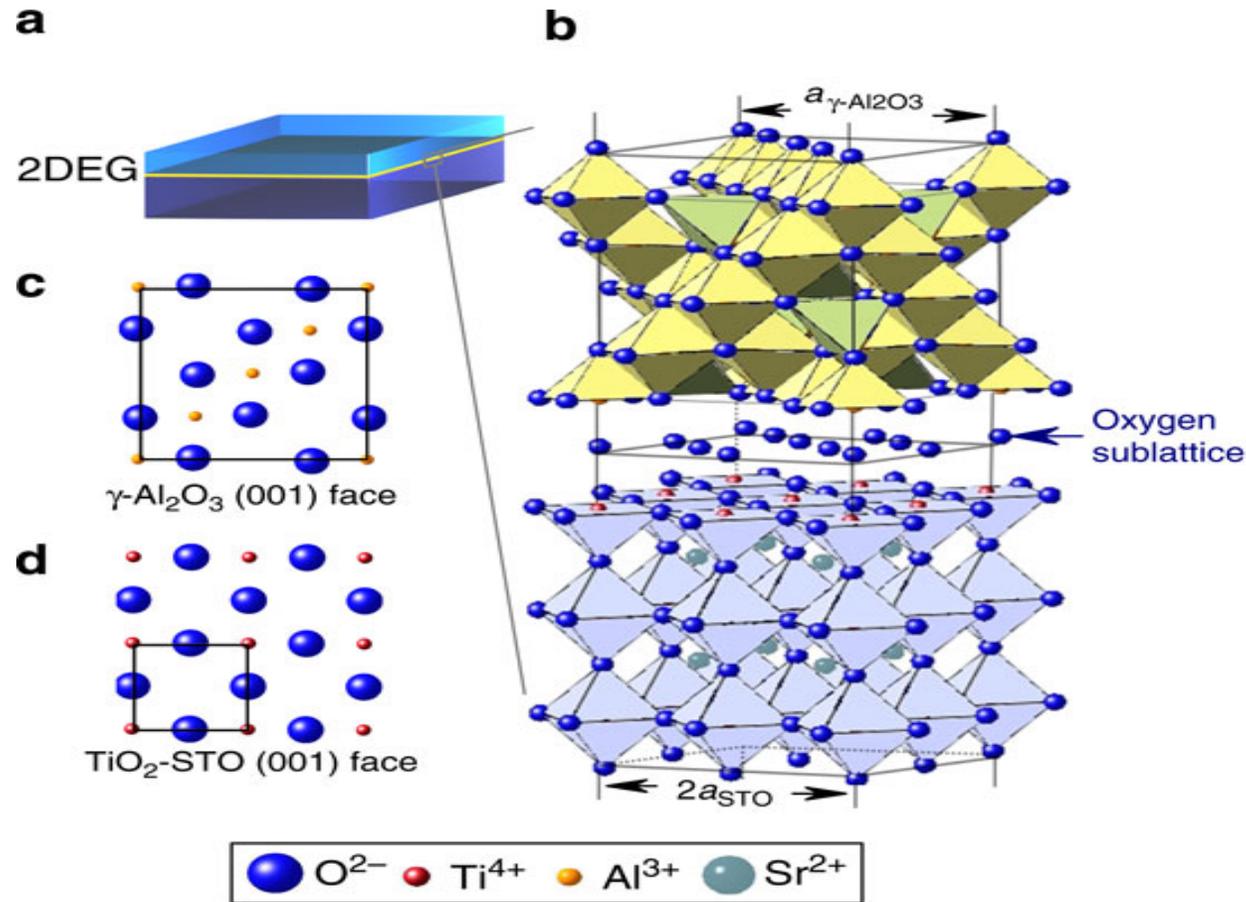
2DEG at GAO/STO interfaces (a system outperform any others)

2.1 Why Alumina (Al_2O_3)?

- Al-based oxides satisfy the criteria for interface redox reaction
- For Al-based oxides, gamma- Al_2O_3 matches perfectly with STO.



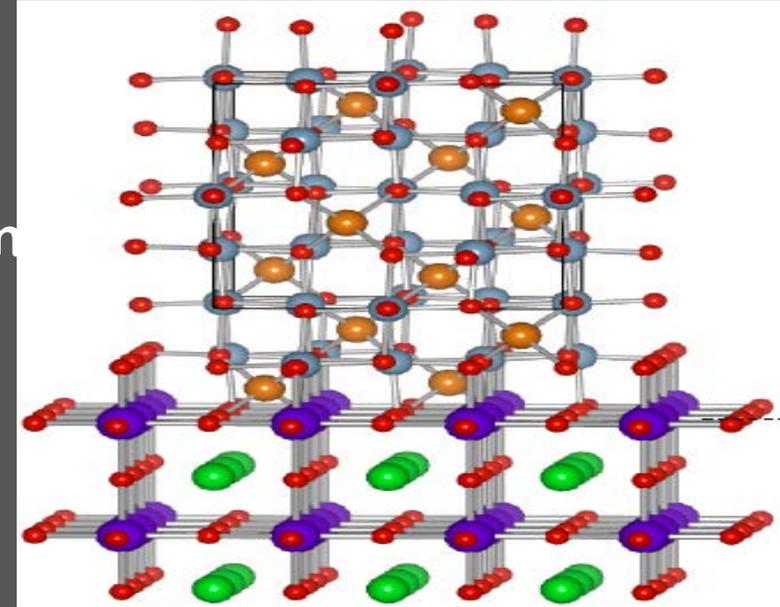
A heretofore unexplored heterointerface between two oxide insulators of Spinel $\gamma\text{-Al}_2\text{O}_3$ and Perovskite SrTiO_3



Y. Z. Chen *et al.* *Nature Communications*, 4:1371, 2394 (2013)

Our γ - $\text{Al}_2\text{O}_3/\text{SrTiO}_3$

1. **New system with perfect lattice match;**
Perovskite/spinel rather than perovskite-type in
2. **Clear 2D character;**
not quasi-2DEG any more.
3. **Highest mobilities;**
4. **Common and cheap materials (without La)**

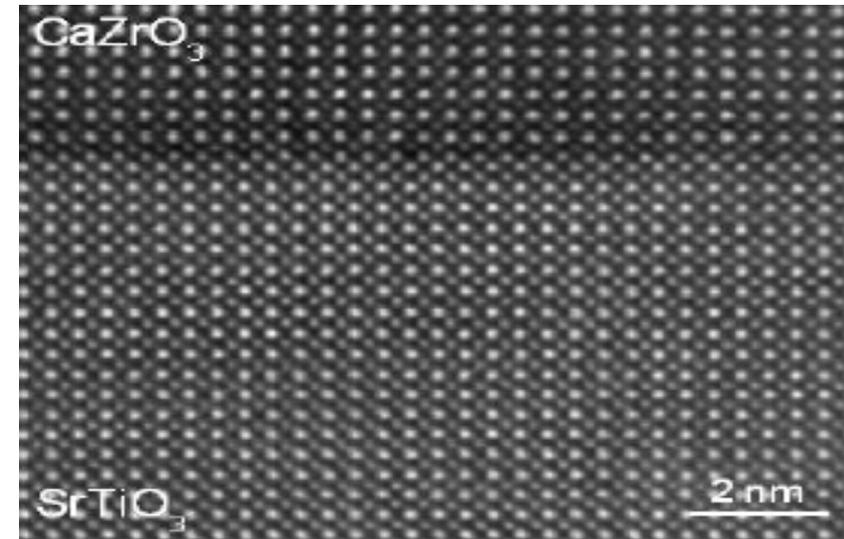
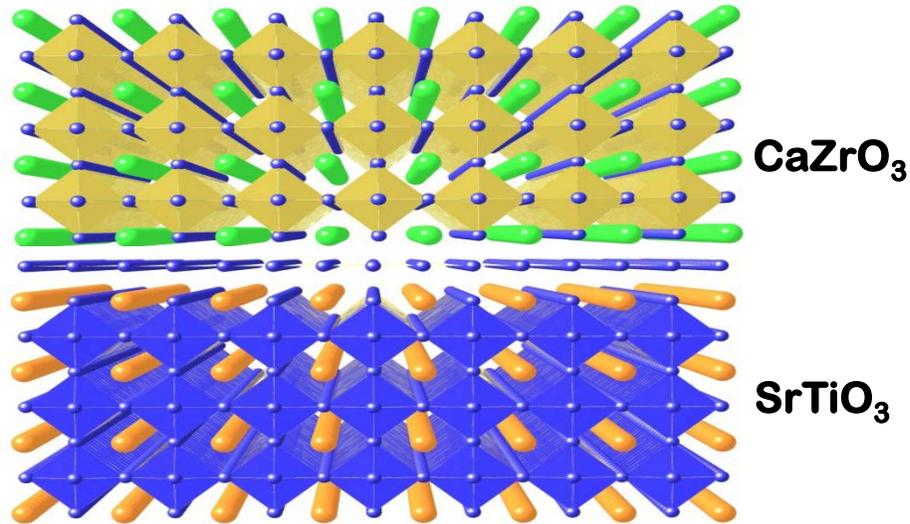


OXIDE INTERFACES

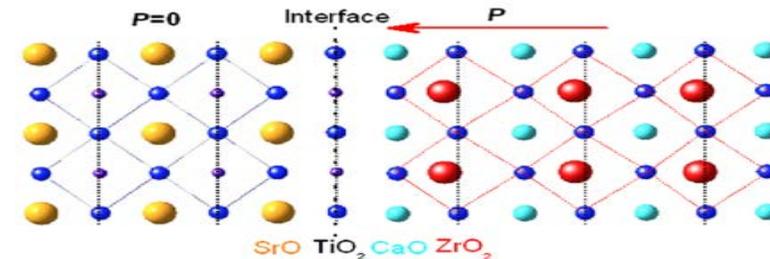
Mismatched lattices patched up

NATURE CHEMISTRY | VOL 8 | APRIL 2016 | www.nature.com/naturechemistry

Use proven principle to create 2DEGs at oxide interfaces.



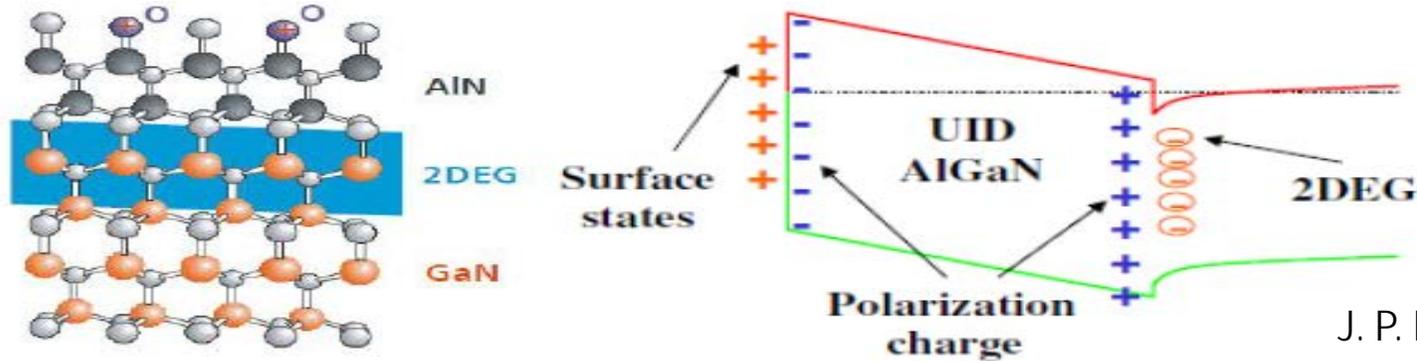
Y. Z. Chen *et al.* *Nano Lett.* **15**, 1849 (2015)



Polarization near the interface.

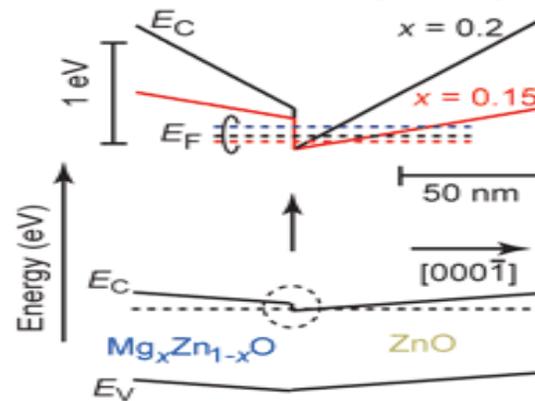
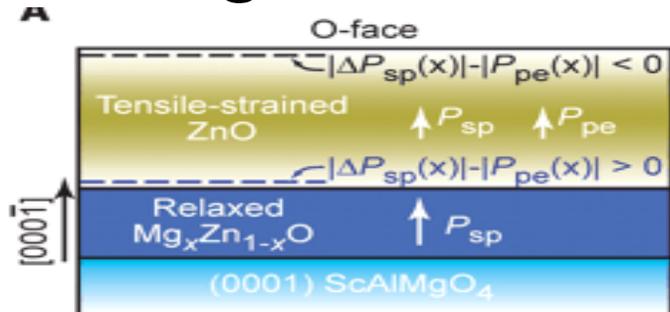
Proven principle to create 2DEGs at semiconductor interfaces: Such as the piezoelectric polarization effect

a. Semiconductor interface (AlGaN/GaN)



J. P. Ibbetson *et al.* APL 77, 250 (2000).

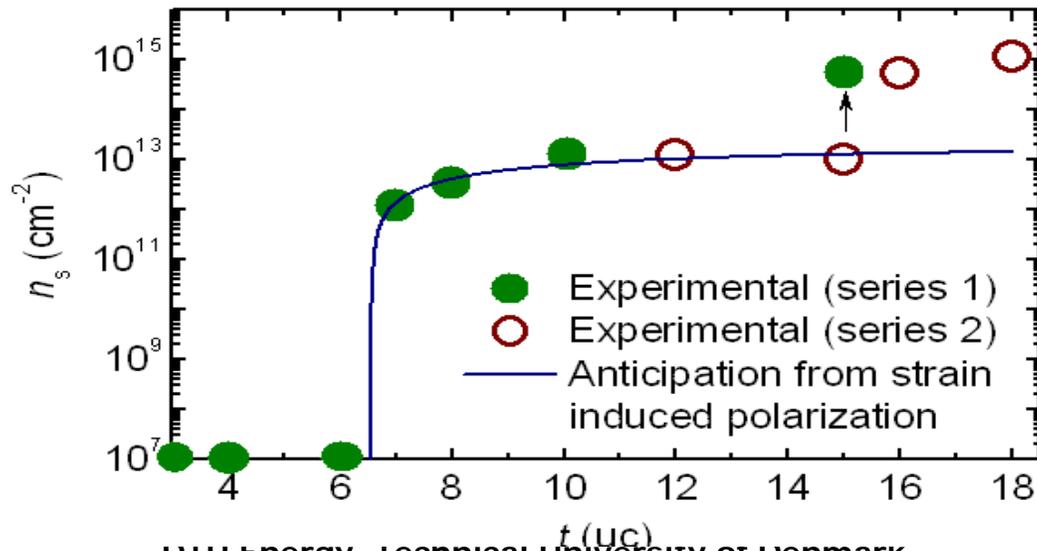
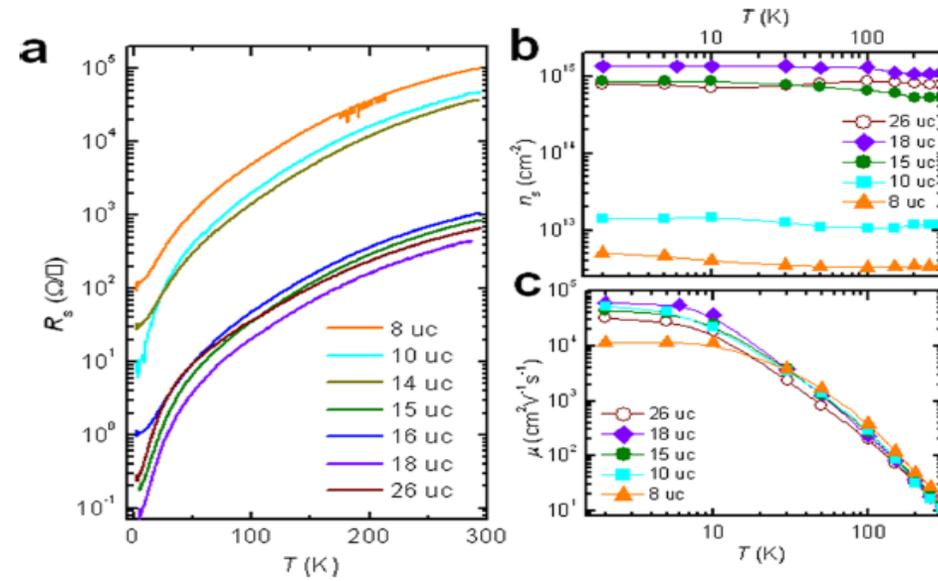
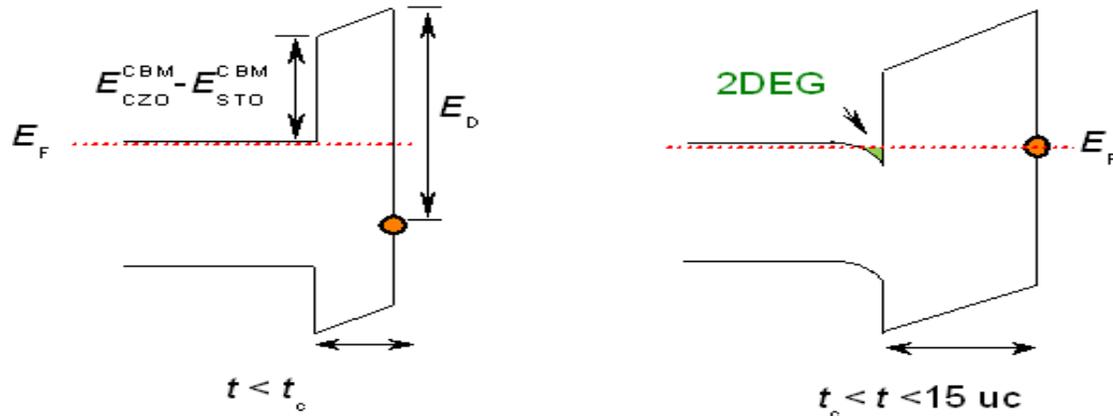
b. ZnO/MgZnO interface



A. Tsukazaki *et al.* Science 315, 1388 (2007)

c. Complex oxide interface: CZO/STO

Polarization effect dominates the interface conduction of CaZrO₃/STO



$$t_c = [E_D - (E_{\text{CBM}}^{\text{CZO}} - E_{\text{CBM}}^{\text{STO}})] \epsilon_0 \epsilon_{\text{CZO}} / eP_{\text{CZO}}$$

$$en_s = P_{\text{CZO}} / (1 - t_c/t)$$

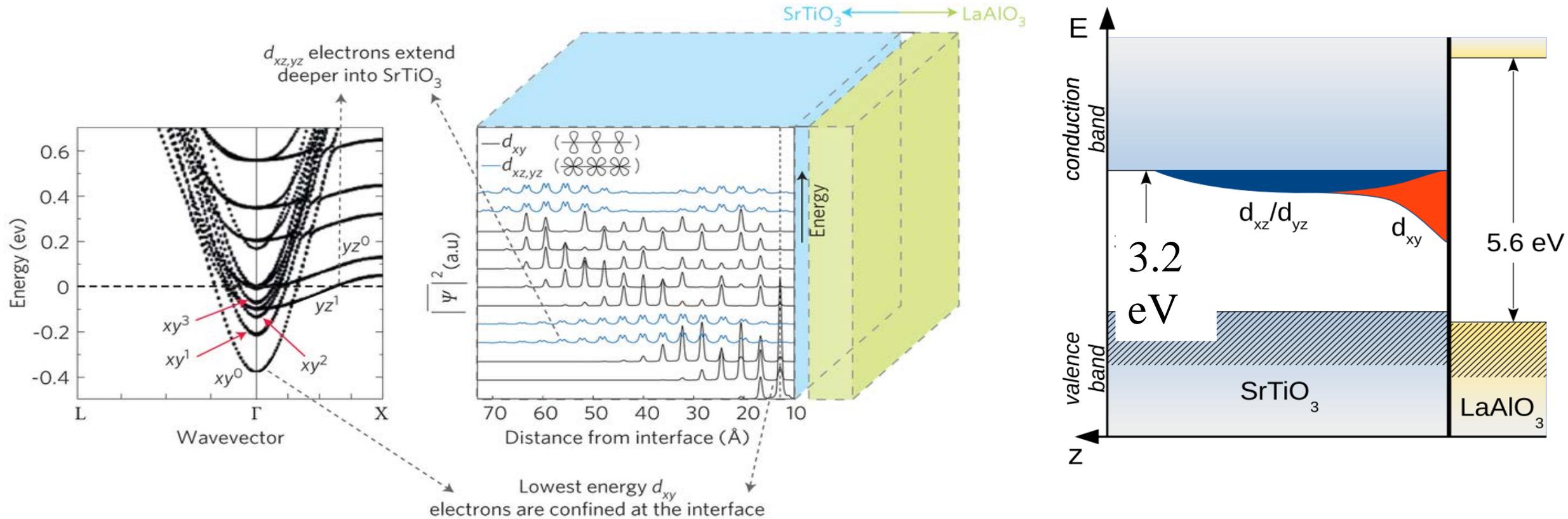
$$P_{\text{CZO}} = 2.3 \times 10^{13} \text{ e/cm}^2 = 3.5 \mu\text{C/cm}^2,$$

$$t_c = 6.5 \text{ uc}$$

Y. Z. Chen *et al. Nano Lett.* **15**, 1849 (2015)

3. Modulation-doping at oxide interface

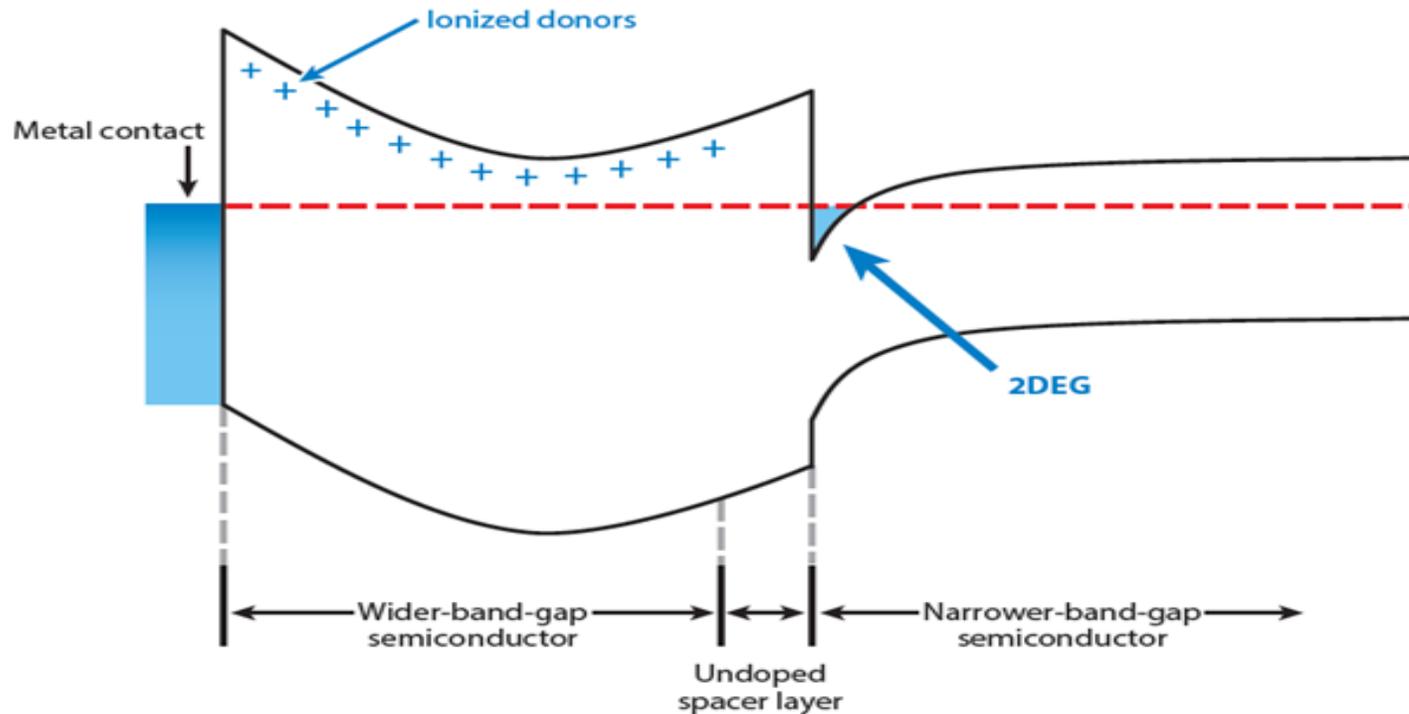
A common problem for STO 2DEL



M. Gabay & J-M Triscone. *Nature Phys.* 9, 610 (2013).

How to further increase the electron mobility of complex oxide interface?

Modulation doping in semiconductors



Semiconductor Interfaces



Vs

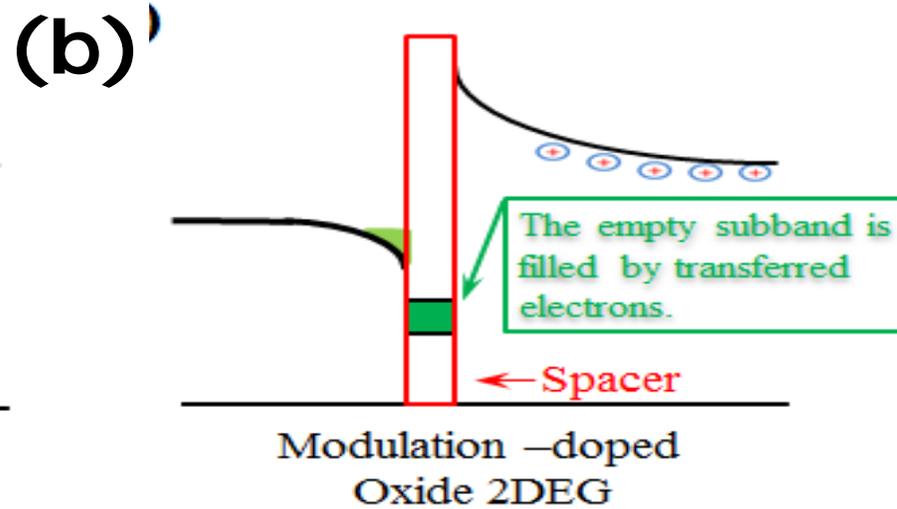
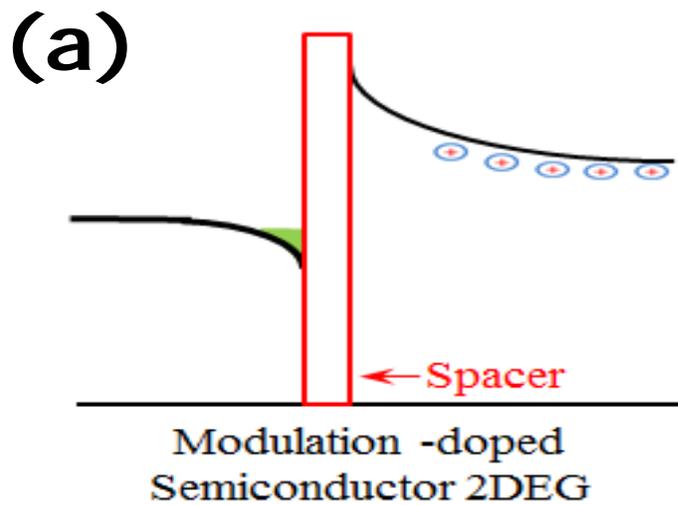
Complex Oxide Interfaces



No mobility gains at oxide interfaces!

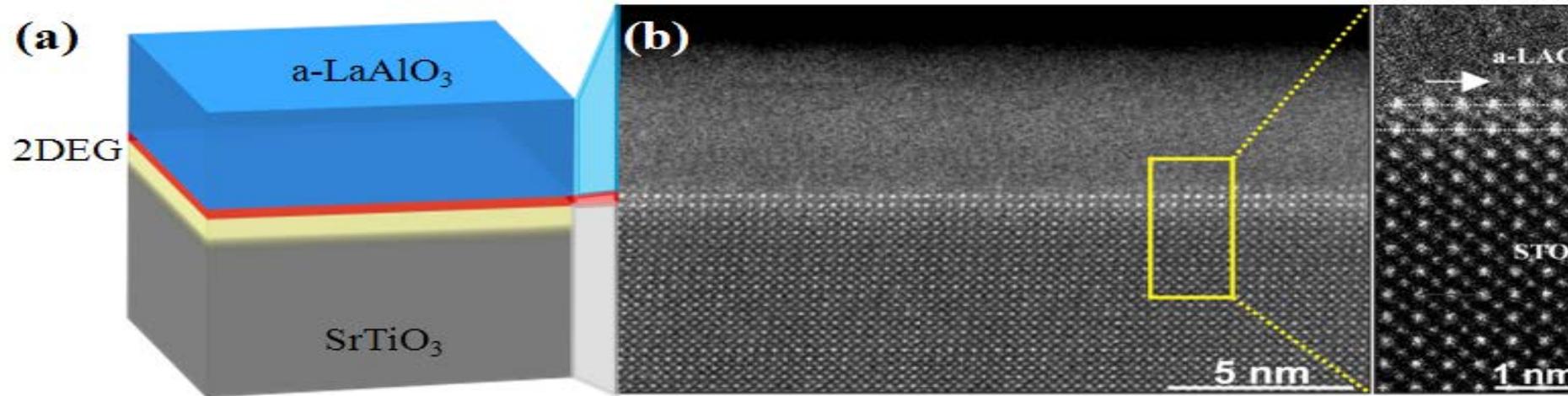
S. Stemmer, S. J. Allen, *Ann. Rev. Mater. Res.* **44**, 151 (2014)

Strategy: Use an electron sink to trap the heavy/slow electrons.

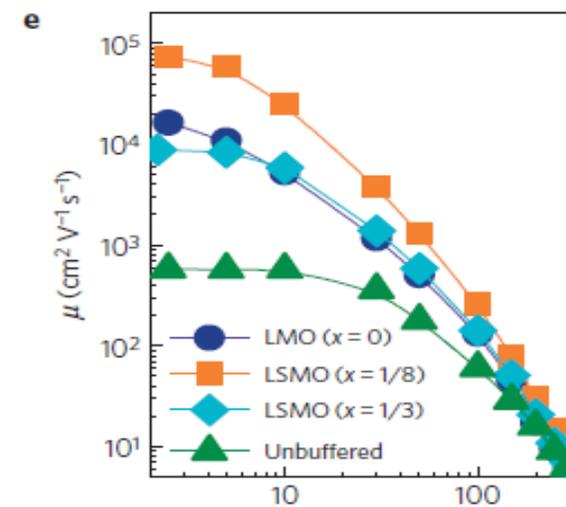
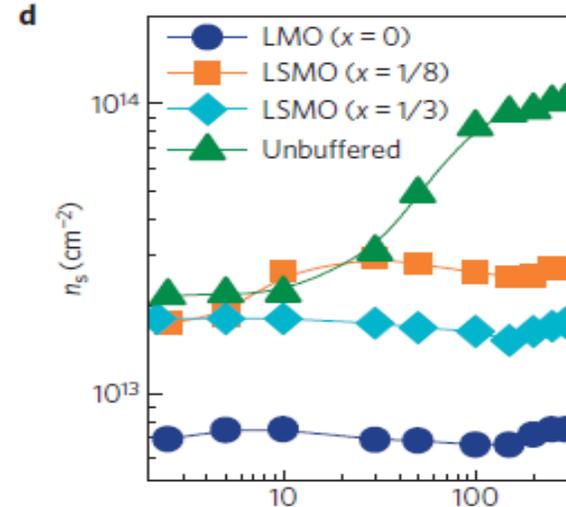
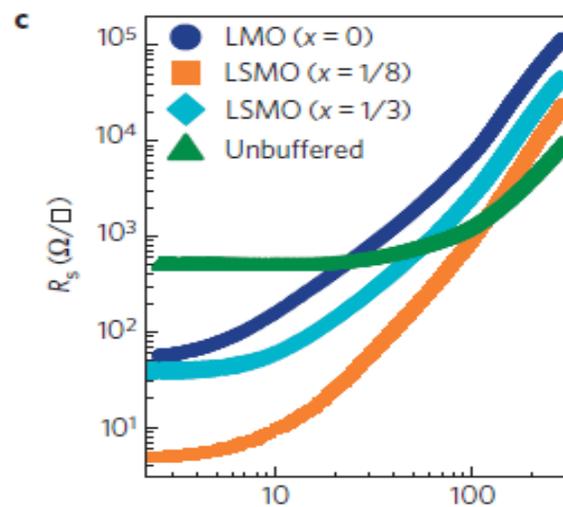


A single unit cell buffered oxide interface:

The first effective modulation doping at complex oxide interfaces.



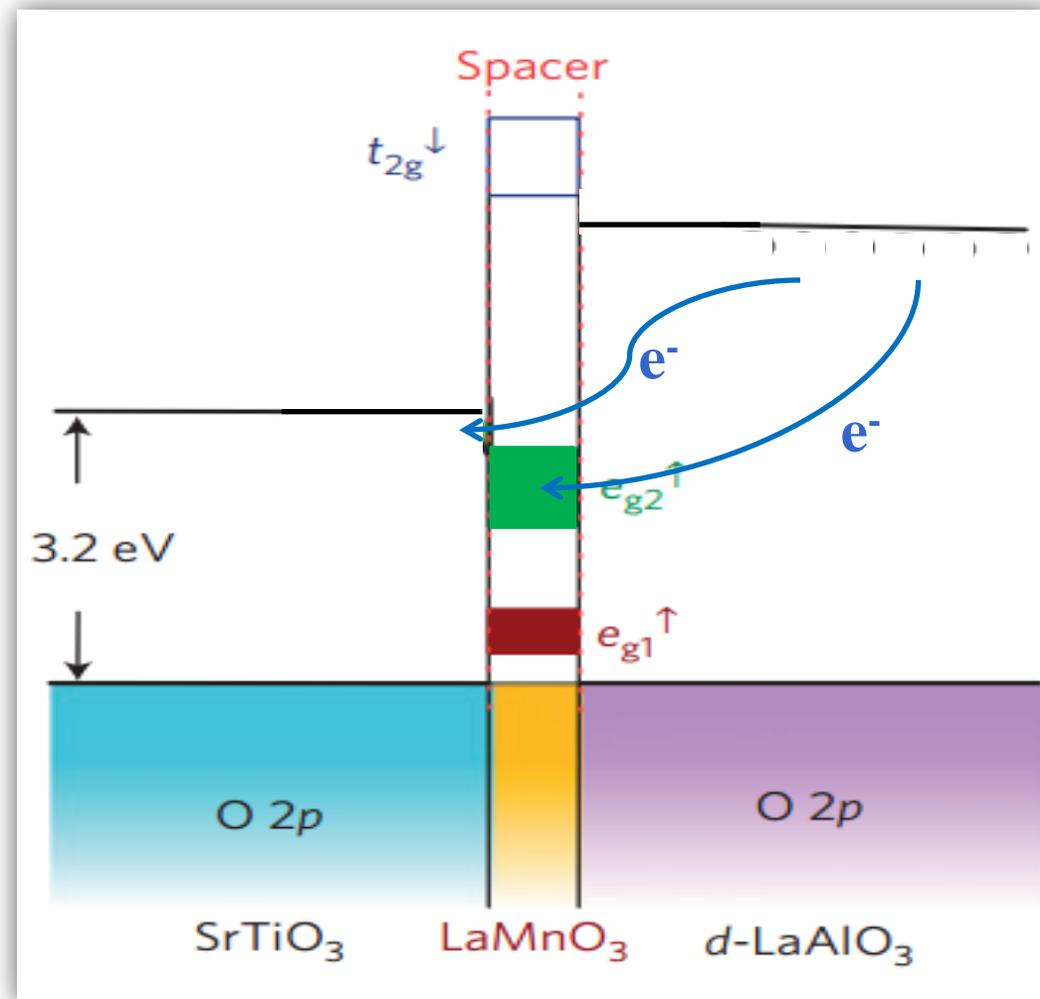
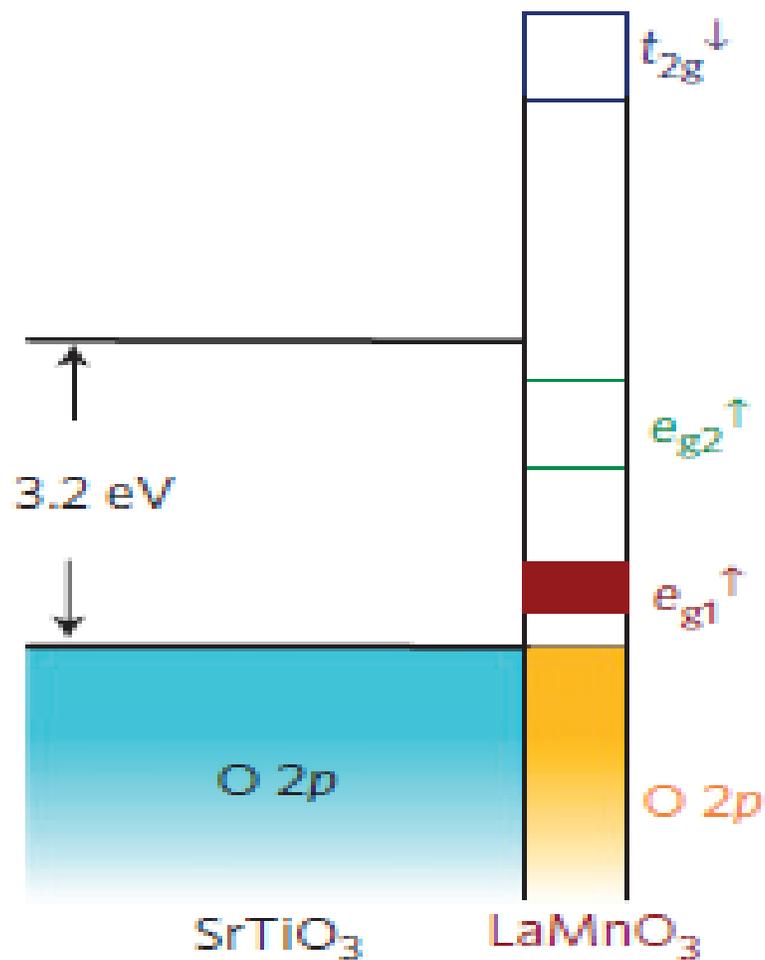
Polar 1 uc
LaMnO₃



Engineered α -LAO/STO samples exhibit a strongly suppressed n_s and Mobility typically is higher than 10 000 $\text{cm}^2\text{V}^{-1}\text{s}^{-1}$ at 2 K (current record, $\mu=73000 \text{ cm}^2\text{V}^{-1}\text{s}^{-1}$).

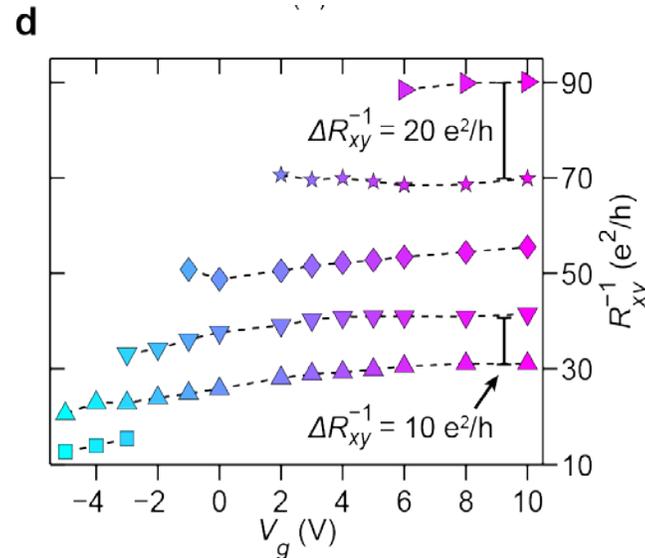
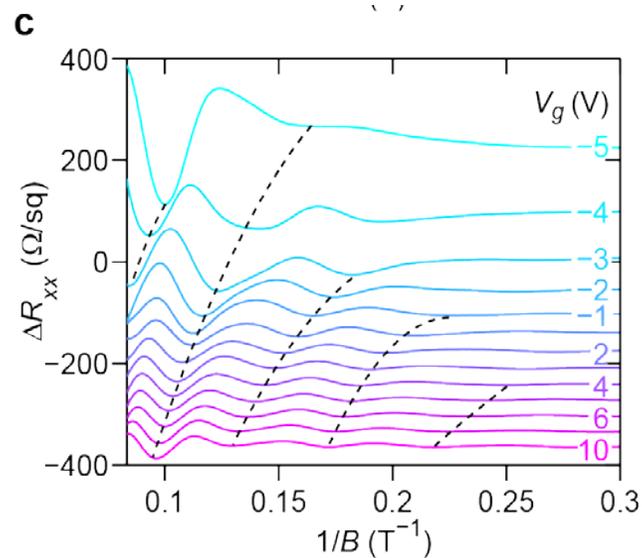
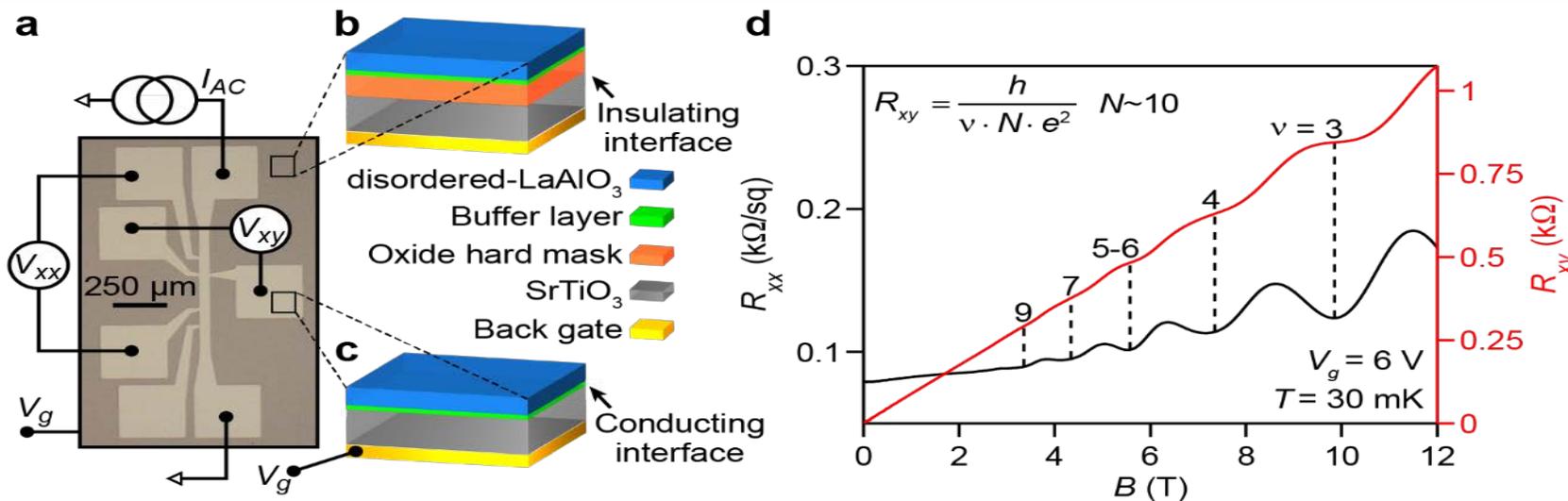
Charge transfer induced modulation doping.

a

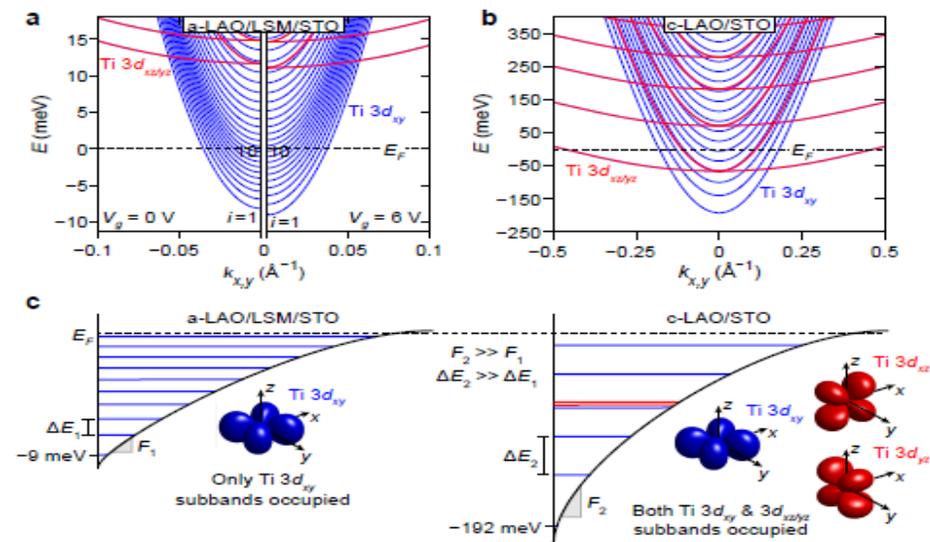


Y. Z. Chen et al. *Nature Mater.* 14(8), 801-806 (2015).

Impact: The observation of Quantum Hall effect at complex oxide interfaces



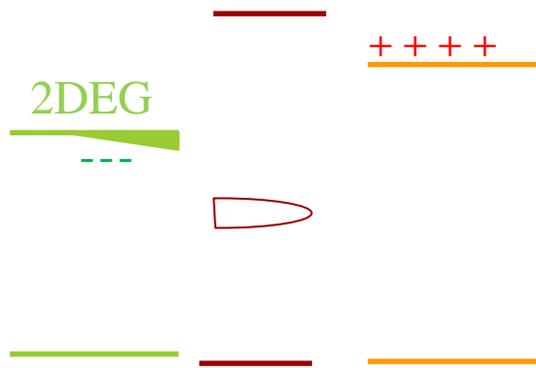
Multiple quantum wells nature



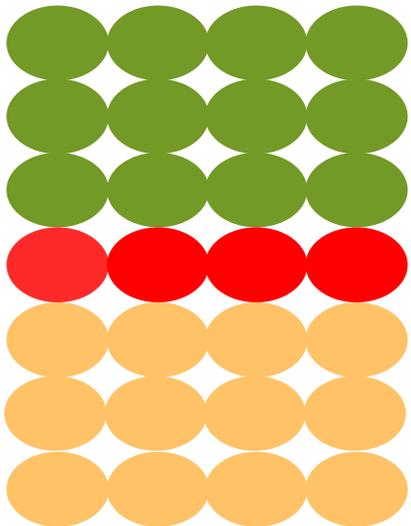
4. Other research:

4.1 Three ways to modulation doping

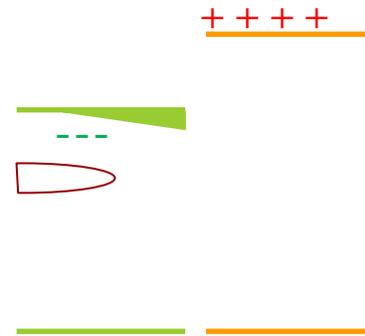
a.



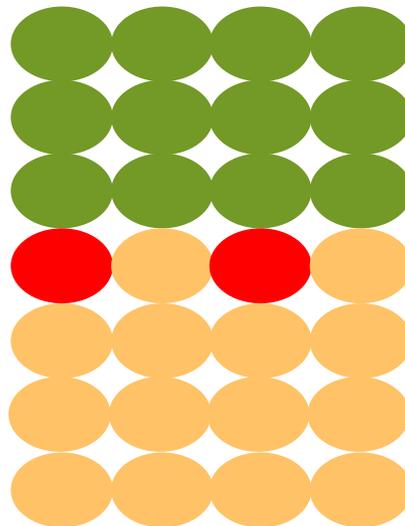
Buffer layer



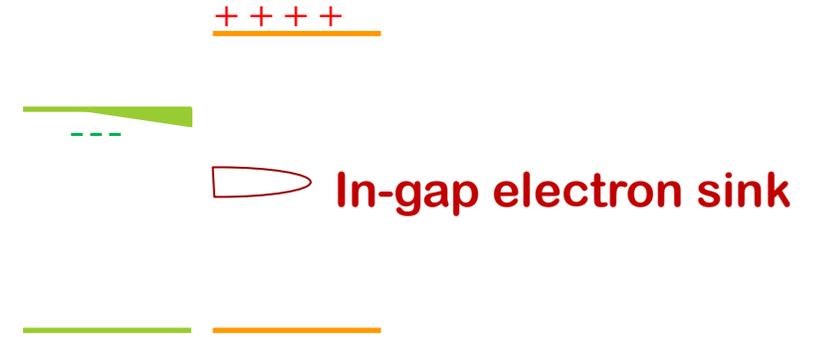
b.



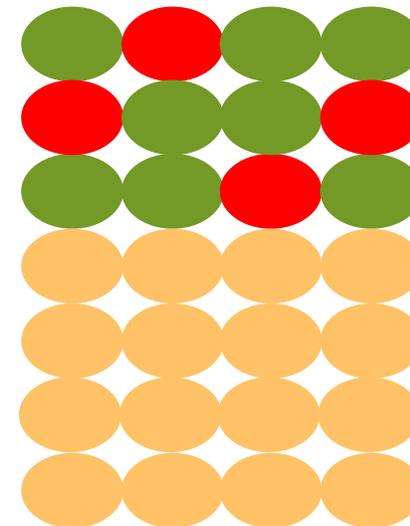
Doping in STO



c.



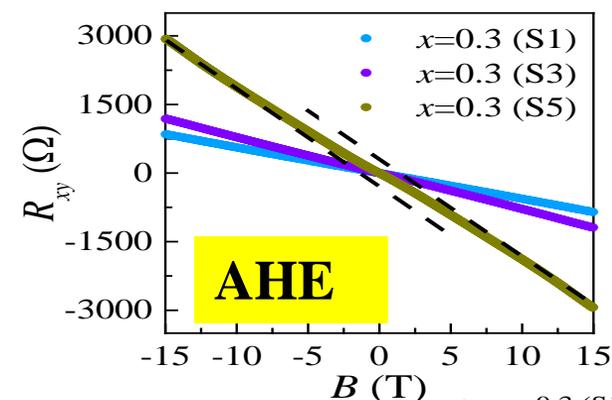
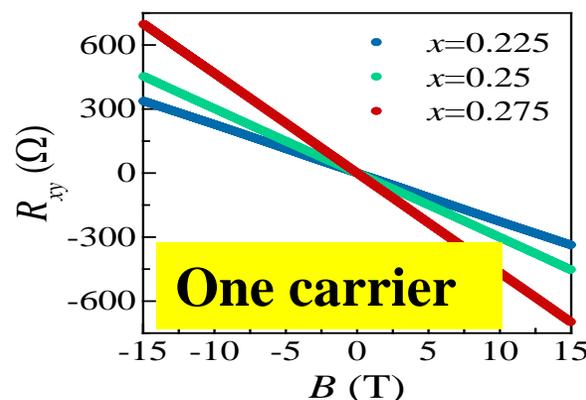
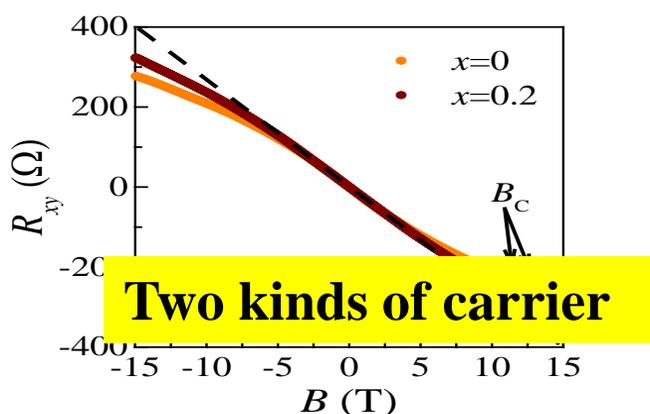
Spatially separated doping



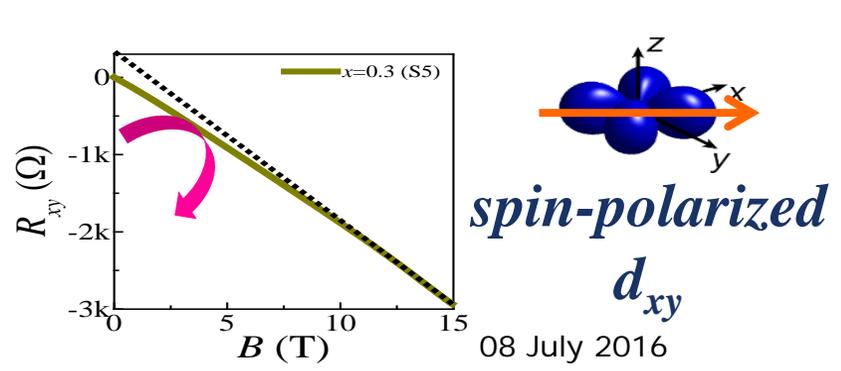
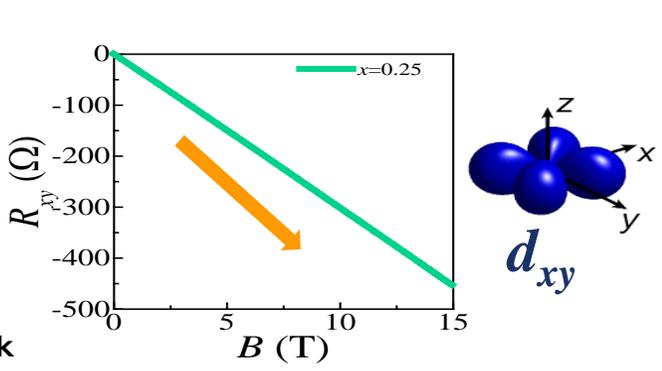
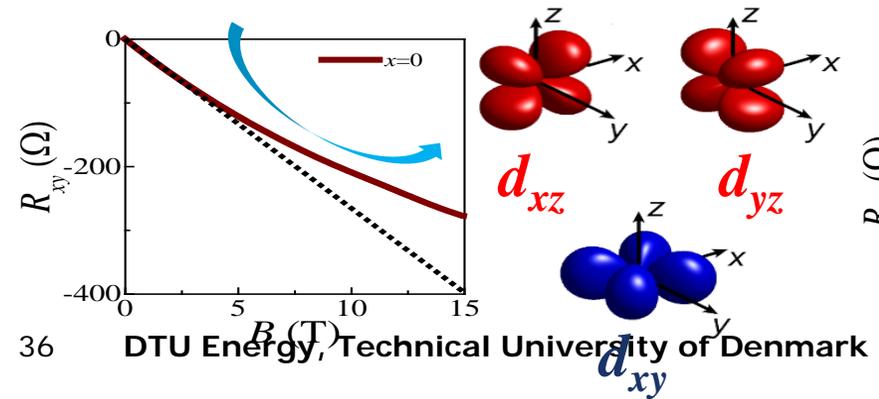
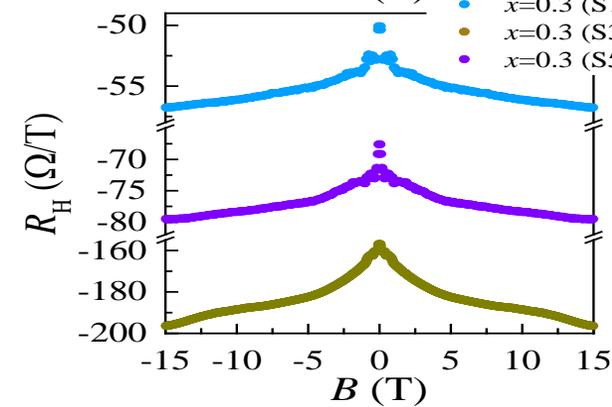
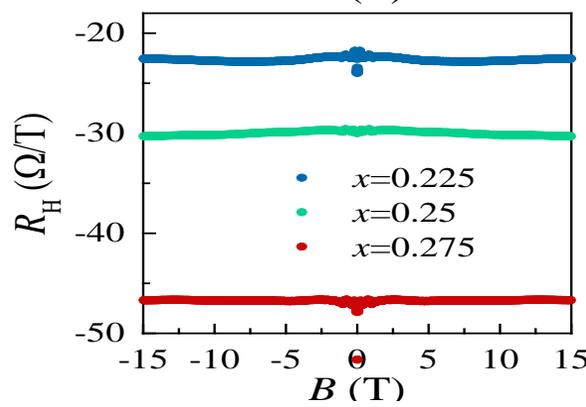
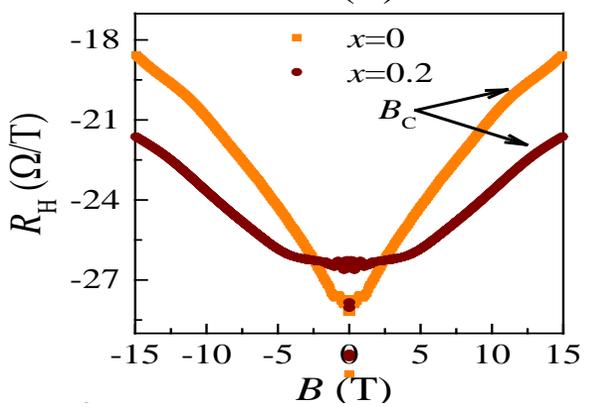
Transport Properties

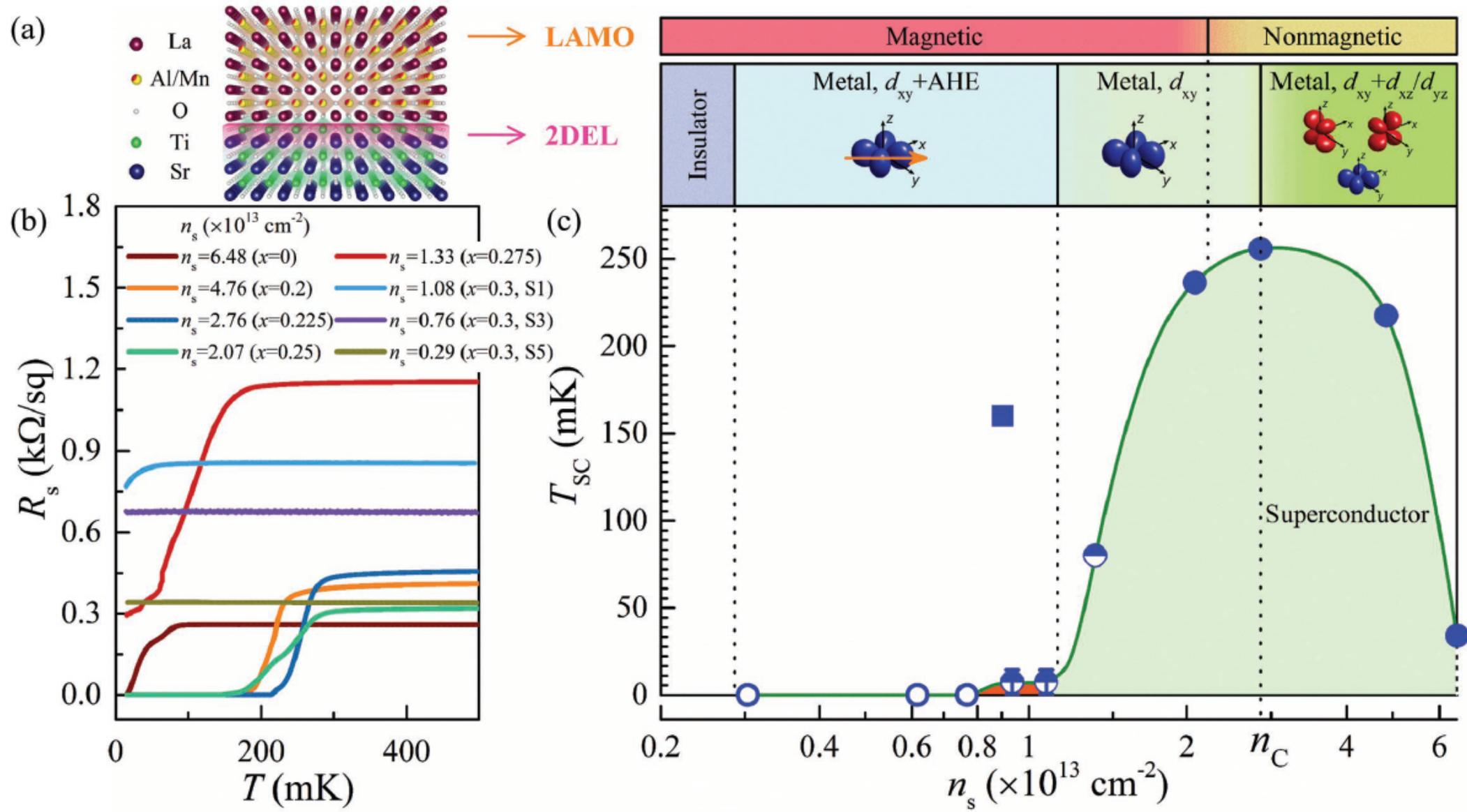


Hall Resistance



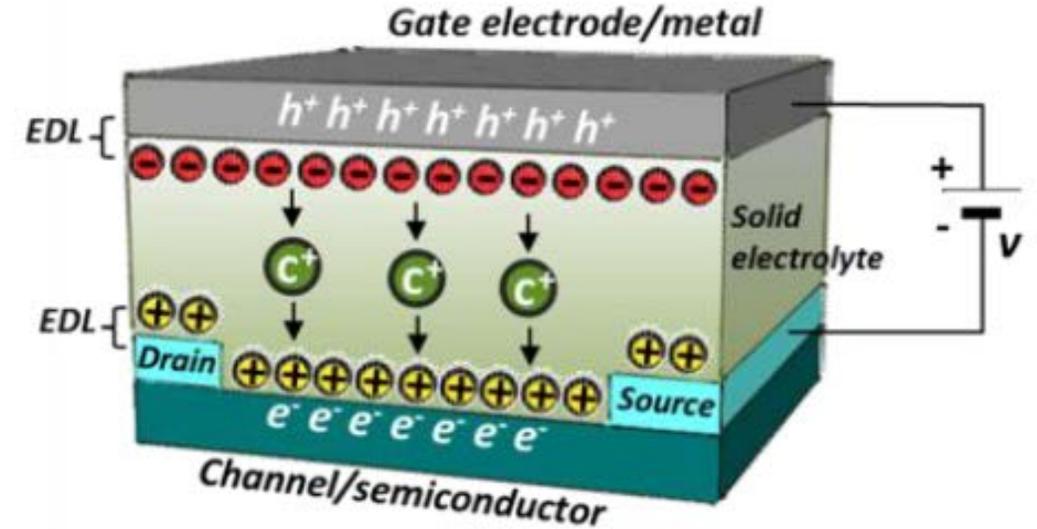
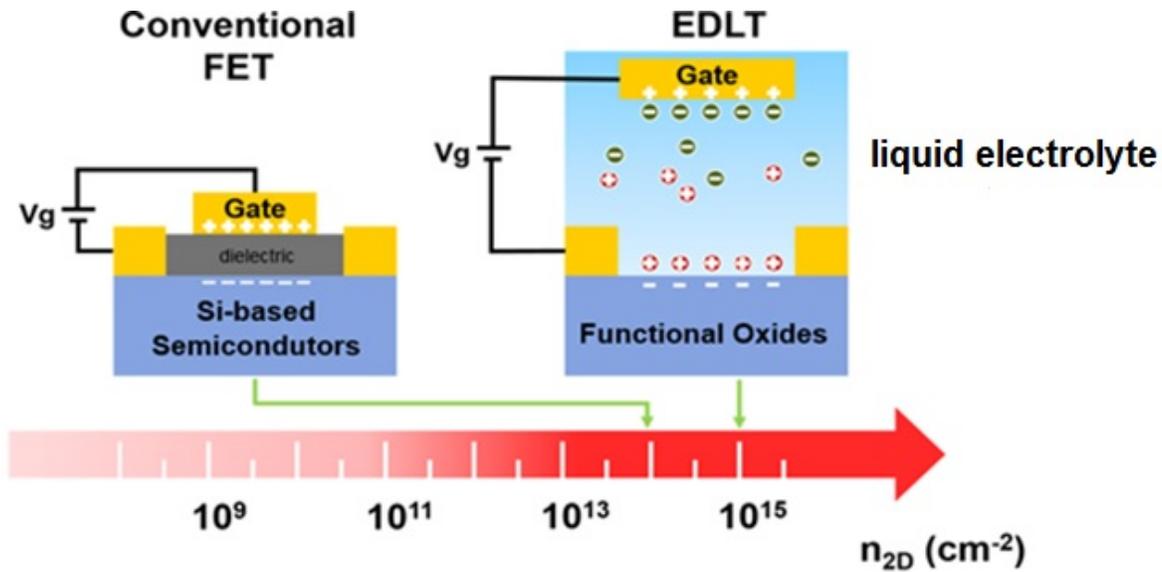
Hall coefficient





4.3 ionic gating

from liquid to solid

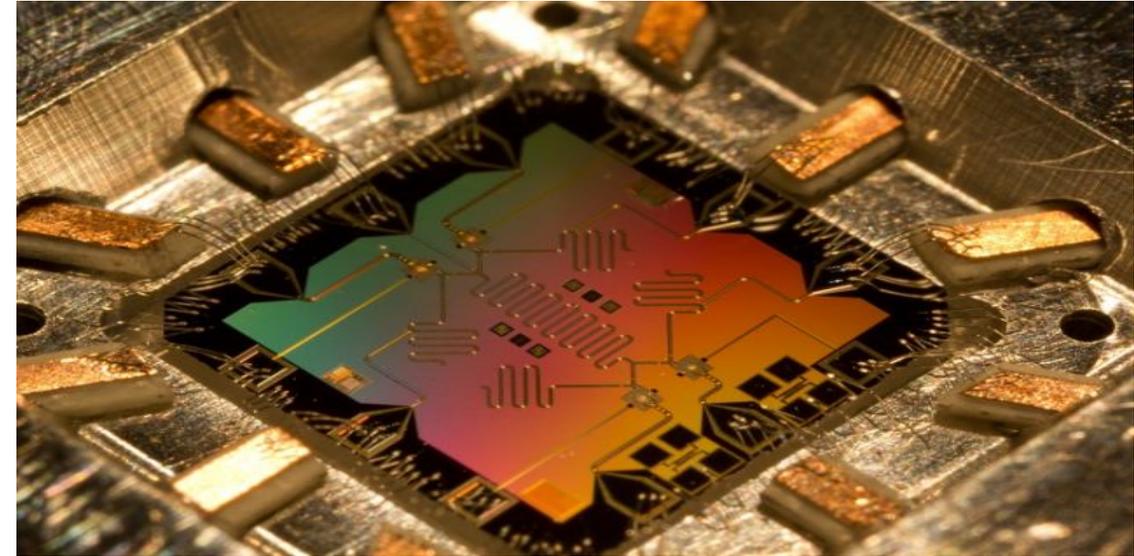
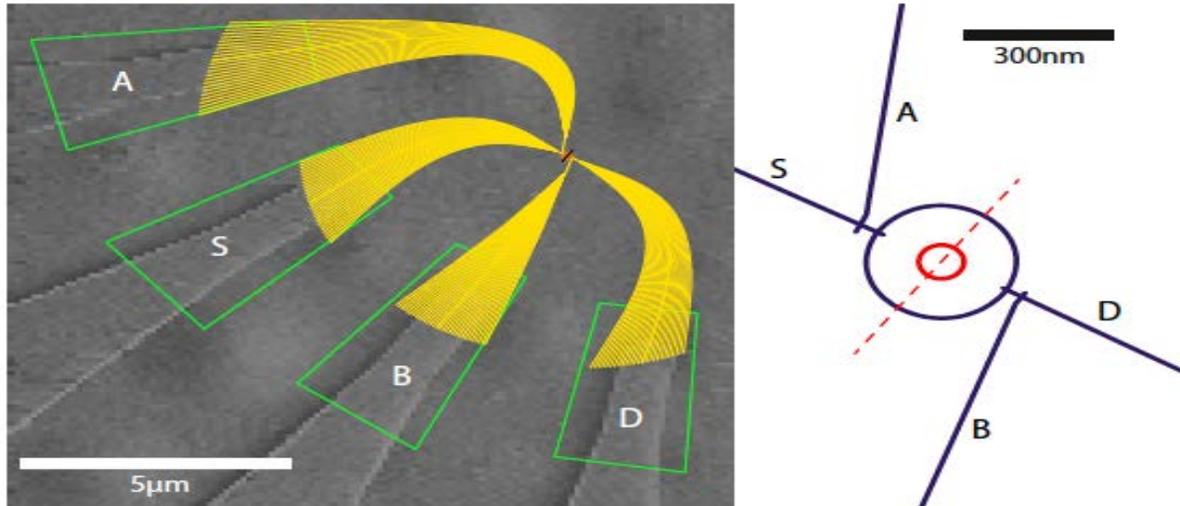
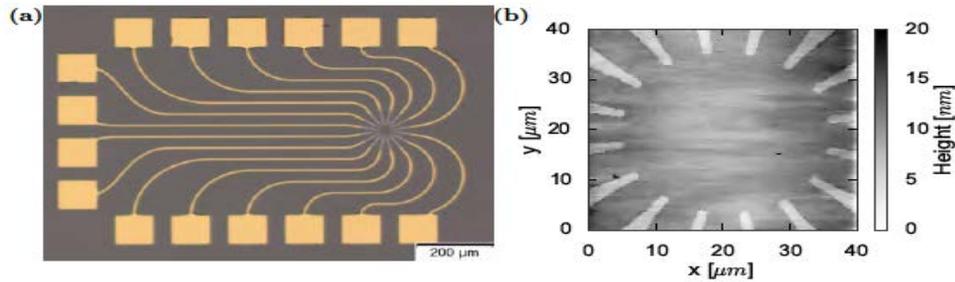


Moving from liquid electrolyte to solid electrolyte

W. Niu et al. *Nano Lett.* 17, 6878-6885 (2017)

5. Perspective on Future Applications

5.1 Quantum devices with strongly-correlated electrons at oxide interfaces.



IBM's quantum processor

Merlin V. Soosten et al.

5.2 It is time to think big!



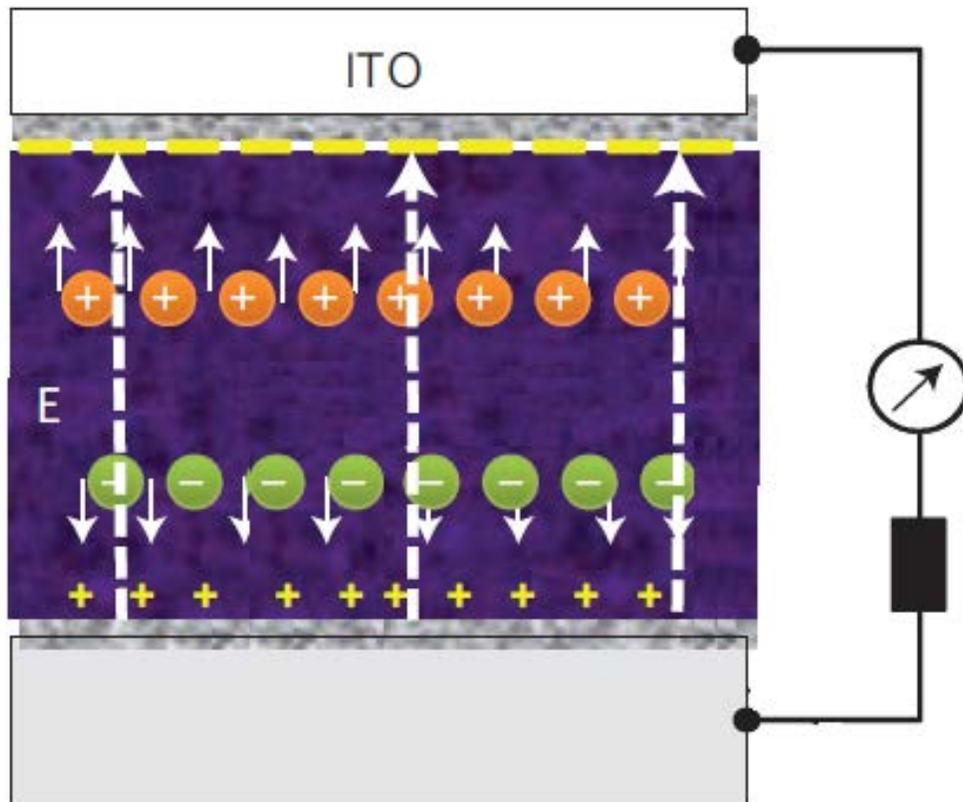
In 20-30 years



How to cope with the intermittency of renewable energy sources?

Emerging technology: Ferroelectric solar cells

Key benefits of Ferroelectric light absorber



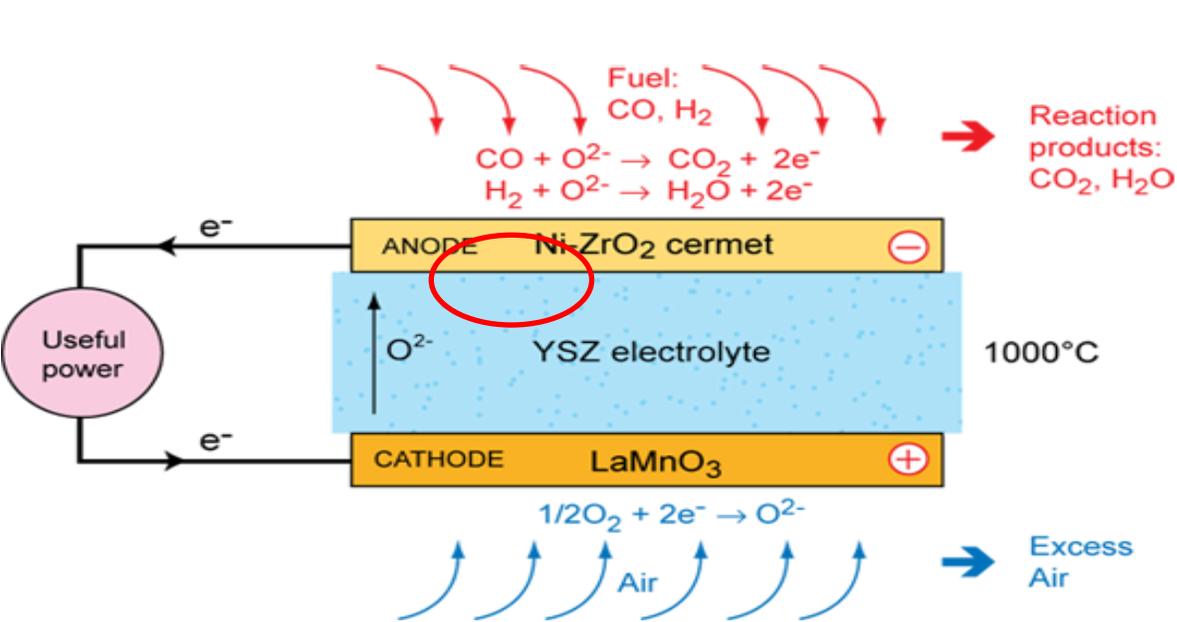
1. Internal fields in ferroelectric materials reduce recombination.

The effective electric field in a ferroelectric material is around one order of magnitude higher than in a p-n junction.

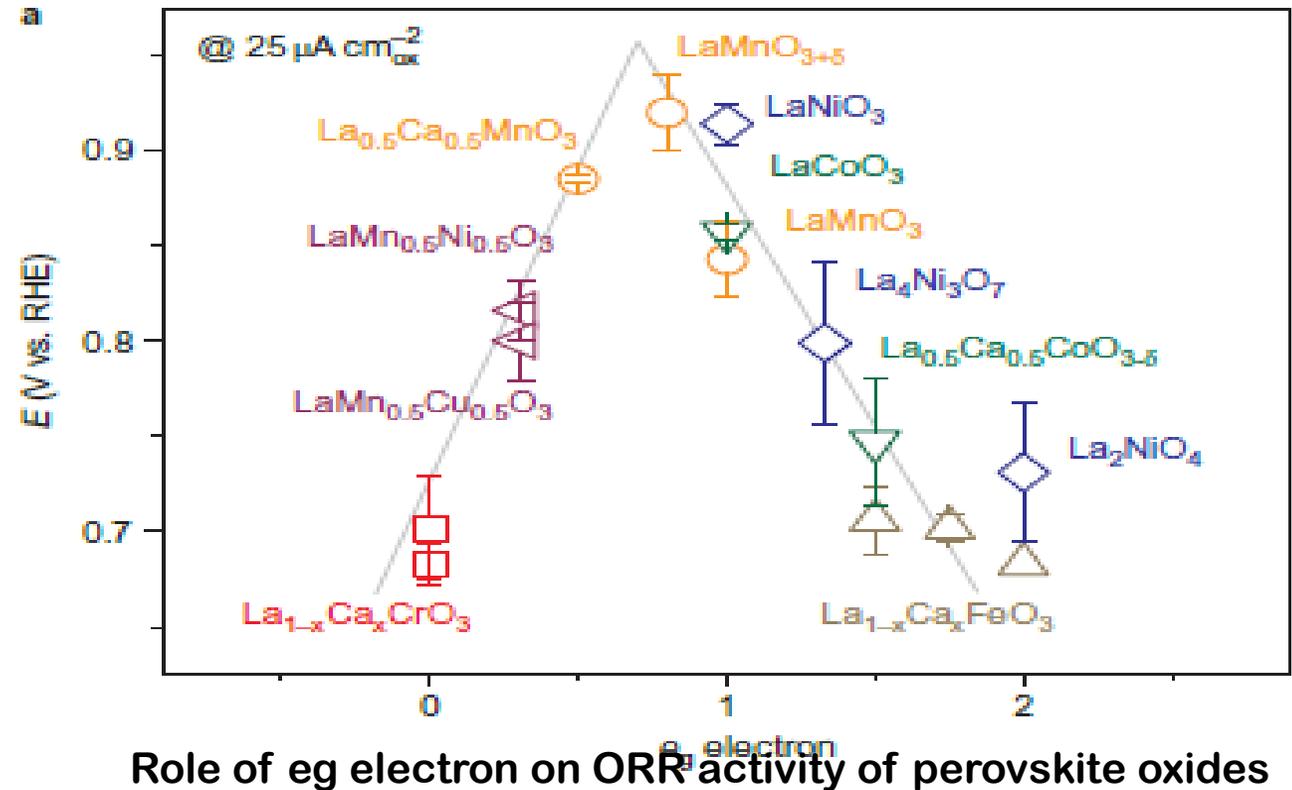
2. Ferroelectric materials can achieve extremely high open circuit voltages (V_{oc}).

5.2 Artificial oxide interfaces as electrocatalysts

The search for highly active and abundant transition-metal-oxide catalysts to replace platinum.



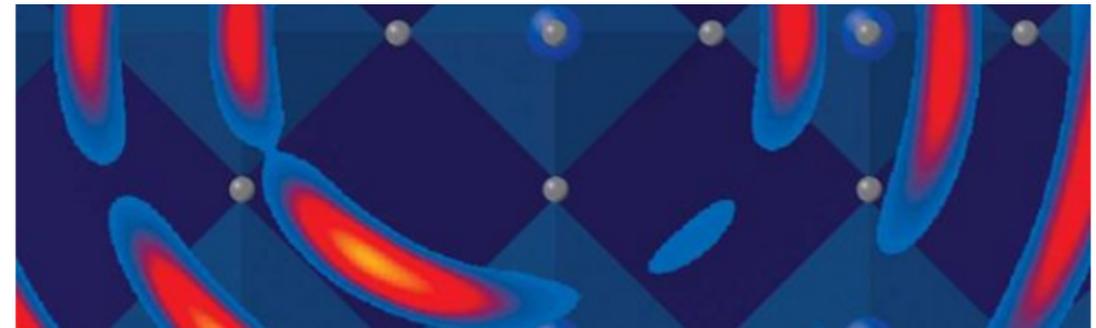
Solid oxide fuel/electrolysis cells



Progress and Perspectives of Atomically Engineered Perovskite Oxide Interfaces for Electronics and Electrocatalysts

Yunzhong Chen and Robert J. Green**

scientists working on a variety of problems at the frontiers of physics, materials science and engineering. The properties of these systems are uniquely defined by quantum mechanical effects that remain manifest at high temperatures and macroscopic length scales.



<https://www.nature.com/collections/ydsxkfVWWS/>

Thank you.